

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
4 December 2003 (04.12.2003)

PCT

(10) International Publication Number
WO 03/100478 A2

(51) International Patent Classification⁷: **G02B 5/02**

(21) International Application Number: PCT/US03/15035

(22) International Filing Date: 13 May 2003 (13.05.2003)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:
10/150,958 20 May 2002 (20.05.2002) US

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(81) Designated States (*national*): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, OM, PH, PL, PT, RO, RU, SD, SE, SG, SK, SL, TJ, TM, TN, TR, TT, TZ, UA, UG, UZ, VN, YU, ZA, ZM, ZW.

(84) Designated States (*regional*): ARIPO patent (GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Published:

— with declaration under Article 17(2)(a); without abstract;
title not checked by the International Searching Authority

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For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.



WO 03/100478 A2

(54) Title: OPTICAL SUBSTRATE AND METHOD OF MAKING

(57) Abstract:

OPTICAL SUBSTRATE AND METHOD OF MAKING

BACKGROUND OF THE INVENTION

This invention relates to optical substrates and, more specifically, to optical substrates having a surface performing at least two optical functions.

In backlight computer displays or other systems, films are commonly used to direct light. For example, in backlight displays, brightness enhancement films use prismatic structures to direct light along the viewing axis (i.e., normal to the display), which enhances the brightness of the light viewed by the user of the display and which allows the system to use less power to create a desired level of on-axis illumination. Films for turning light can also be used in a wide range of other optical designs, such as for projection displays, traffic signals, and illuminated signs.

Backlight displays and other systems use layers of films stacked and arranged so that the prismatic surfaces thereof are perpendicular to one another and are sandwiched between other optical films known as diffusers. Diffusers have highly irregular surfaces.

SUMMARY OF THE INVENTION

The invention features a multiple function optical substrate and a method of making the same. Under one aspect of the invention, the optical substrate includes a three-dimensional surface characterized by a function such as a correlation function, $R(x,y)$, having a value of less than about 37 percent ($1/e$) of the initial value of R within a correlation length, l_c , of about 1 cm or less. The three-dimensional surface is defined by a first surface structure function modulated by a second, random, or at least pseudo-random, function. The properties of the first surface structure function produce a specular component from a first input beam of light, and this light turning behavior is retained in the three-dimensional surface. Generally, the pseudo-random function is a signal that modulates any combination of the frequency, height, peak angle or phase of the first surface structure function. A window is defined and points are randomly selected within the window thereby creating a modulation path

connecting the randomly selected points. A master function is defined and a surface function is generated along the modulation path and repeatedly combined with a master function at successive locations within the master function. The resulting three-dimensional surface of the substrate retains the light turning characteristics of the first surface structure function, but also diffuses light to, for example, reduce Moiré artifacts.

In another aspect of the invention, the optical substrate is applied to one or more sides of a film used for brightness enhancement in a backlight panel light guide. The optical substrate also produces an on-axis increase in brightness of at least 30 percent in the brightness enhancement application. In addition, the three-dimensional surface produces diffused specular components of light with a power half angle of between about 0.1 and 60 degrees.

BRIEF DESCRIPTION OF THE DRAWINGS

FIGURE 1 is a cross-sectional view of a prior art film in which a series of prismatic structures are used to turn light.

FIGURE 2 is a top view of an optical substrate according to one embodiment of the invention.

FIGURE 3 is a top view of a second optical substrate according to another embodiment of the invention.

FIGURE 4 is a perspective view of the optical substrate of FIGURE 3.

FIGURE 5 is a graphical representation showing three cross-sectional views of an optical substrate according to one embodiment of the invention.

FIGURE 6 is a cross-sectional view of an optical substrate according to one embodiment of the invention showing the turning and diffusing of light beams.

FIGURE 7 is a perspective view of a flat panel display.

FIGURE 8 is a top view of a single waveform that can be used to model an optical substrate according to one embodiment the invention.

FIGURE 9 is a plot showing the variation in phase along the length of the waveform depicted in FIGURE 8.

FIGURE 10 is a plot showing the variation in peak angle along the length of the waveform depicted in FIGURE 8.

FIGURE 11 is a surface structure formed after performing a first iteration of placing modulated waveform structures on a master image.

FIGURE 12 is a surface structure formed after performing a second iteration of placing modulated waveform structures on the structure of FIGURE 11.

FIGURE 13 is a representation of a randomized substrate surface.

FIGURE 14 is a schematic representation of control points randomly located within a window for generating a modulated waveform.

FIGURE 15 is a representation of the modulated waveform of FIGURE 14 applied to a master function.

FIGURE 16 is a flow chart of the method of generating a random substrate surface.

FIGURE 17 is a representation of the tiling of the random substrate surface on a wafer.

FIGURE 18 is the top view of a height map of a 40 um pitch prism array.

FIGURE 19 is a normalized auto correlation function of a horizontal section of the 40 um pitch prism array of FIGURE 18.

FIGURE 20 is the top view of a Moiré map of the 40 um pitch prism array of FIGURE 18 with a 50 um pitch reference prism.

FIGURE 21 is a profile of the Moiré map of FIGURE 20.

FIGURE 22 is the top view of a height map of the 40 um pitch prism array of FIGURE 18 with randomization in the horizontal position of the prism centers.

FIGURE 23 is a normalized auto correlation function of a horizontal section of the height map of FIGURE 22.

FIGURE 24 is the top view of a Moiré map of the height map of FIGURE 22.

FIGURE 25 is a profile of the Moiré map of FIGURE 24.

FIGURE 26 is the top view of a height map of the 40 um pitch prism array of FIGURE 18 with full cycle randomization in the horizontal position of the prism centers with superimposed phase modulated prism wave forms.

FIGURE 27 is a normalized auto correlation function of a horizontal section of the height map of FIGURE 26.

FIGURE 28 is the top view of a Moiré map of the height map of the 40 um pitch prism array of FIGURE 26.

FIGURE 29 is a profile of the Moiré map of FIGURE 28.

FIGURE 30 is the top view of a Moiré map of a 40 um pitch prism array with a 44um pitch prism array.

FIGURE 31 is the top view of a Moiré map of a 40 um pitch prism array with randomization in the horizontal position of the prism centers with a 44um pitch prism array.

FIGURE 32 is the top view of a Moiré map of the height map of Figure 26 against a 44 um pitch reference prism array.

FIGURE 33 is the vertical auto correlation of the height map of the 40 um pitch prism array of FIGURE 26.

FIGURE 34 is the vertical auto correlation of the height map of the 40 um pitch prism array of FIGURE 22.

FIGURE 35 is a graphical representation of a carrier wave, $c(x)$ modulated in amplitude by a random function.

FIGURE 36 is a graphical representation of a carrier wave, $c(x)$ modulated in phase by a random function.

FIGURE 37 is a first graphical representation of a carrier wave, $c(x)$ modulated in frequency by a random function.

FIGURE 38 is a second graphical representation of a carrier wave, $c(x)$ modulated in frequency by a random function.

FIGURE 39 is a graphical representation of frequency and amplitude modulation with spatially varying carrier and noise functions.

FIGURE 40 is an image of a skeleton mask function.

FIGURE 41 is a sectional view of a backlight display device.

DETAILED DESCRIPTION OF THE INVENTION

The embodiments of the invention provide an optical substrate for turning and diffusing light using the surface thereof. The substrate includes a surface defined by a first surface structure function for turning light and a second surface structure function for diffusing light. The combination of these two surface functions results in a single three-dimensional surface that both turns and diffuses light.

Embodiments of substrates will be described below with respect to brightness enhancing films for use in backlight displays or the like. The optical substrates, however, can be used in a wide variety of other applications as well.

Figure 1 depicts in cross section a prior art film in which a series of prismatic structures 10 are used to turn light. In backlight displays, light enters surface 20 and

exits surface 30. In the film of Figure 1, a beam of light, *A*, having a zero degree angle of incidence to the light-entering surface 20 is directed off the prism structures 10 and is, essentially, reflected back toward the input. A second beam of light, *B*, having an angle of incidence of θ is turned by the prismatic structures 10 so that it is transmitted through the light-exiting surface 30 and exits substantially normal to the light-entering surface 20. Other beams (not shown) will turn or reflect at other angles. The bulk statistical properties of such a film are characterized by parameters such as optical gain and viewing angle.

In this prior art film, the surface 30 can be described as a function. If the height of the surface 30 relative to surface 20 is coordinate *z* and the coordinates across the page and normal to the page are *x*, *y* respectively, then the surface 30 can be defined by a function $z = f(x,y)$. In this case, $f(x)$ is a repeating triangular waveform, or sawtooth, with a constant offset relative to surface 20. In this case, the function defining surface 30 has a special geometry that both turns and reflects light as outlined above.

Figure 2 is a top view of an optical substrate 40 according to a first embodiment of the invention. The embodiment of Figure 2 shows a portion of a substrate 40 that has a length, *l*, of about 2,000 microns and a width, *w*, of about 2,000 microns. Figure 3 is a top view of an embodiment of a portion of a substrate 42 that is about 500 microns by 500 microns in dimension, and Figure 4 shows a perspective view of a portion of the substrate 42 of Figure 3. The embodiments of Figures 3 and 4 have a three-dimensional surface that is more highly irregular than the three-dimensional surface of Figure 2. Generally, the substrates shown in Figures 2-4 have an irregular three-dimensional surface structure on the light-exiting surface thereof. Because of its geometry, the irregular three-dimensional surface structure, turns light to produce output specular components, while at the same time diffusing light and having a low correlation length, l_c . Because the embodiments of the substrates can turn and diffuse light on a single surface, separate diffusion surfaces can be eliminated in some applications.

The substrates shown in Figures 2-4 have an irregular three-dimensional surface. This irregular surface, however, is not easily defined by well known mathematical functions, as is the case for the light exiting surface 30 of Figure 1. Instead, this surface function is better defined as the result of modulating a first surface structure function by a second surface function, and in some cases by taking such modulated functions and superimposing them with other functions formed similarly. For example, the first function can be similar to that defined by the light exiting surface 30 of Figure 1. The first function may also be that of a single prism. The second function can be a pseudo-random function of height, phase, frequency or peak angle. Moreover, the combination can be accomplished by way of modulating the first function by the second function so that the resulting function $z = f(x,y)$ of substrate 40 has a pseudo-randomly varying height, phase, frequency or peak angle along the “ l ” direction of the substrate 40 (Figure 2). The first function provides the geometrical properties to turn or reflect light and the second function provides the geometrical properties to diffuse the turned light or reflected light. As will be discussed below, other functions can be substituted and other parameters can be relevant (e.g., the phase of an entity). If a prismatic surface function is used as the first function, the height, h , width, s , and peak angle, α , of the first surface function can vary depending on the intended use of the substrate. In addition, the first surface function need not be the symmetric structures as shown in Figure 1.

In one embodiment, the first surface structure function is modulated in phase, frequency, peak angle or height by the second surface structure function. The second surface structure function defines the type of modulation, to produce the three-dimensional surface of the film on the light-exiting surface 41 (Figure 2) of the substrate 40. The surface height of the light-exiting surface 41 of the substrate 40 is therefore defined by the combination of these two surface structure functions. For example, the height of the peak of one or more of the first surface structure functions, e.g., prisms can be modulated along the length l of the substrate 40. The height can be randomly or pseudo-randomly modulated between certain limits at random or fixed intervals along the length, l , of the substrate 40. As best understood, the term random means true randomness or randomness to the extent possible when generated by

human means, e.g., pseudo-randomness. In another example, the phase, i.e., the horizontal position along the width w of the substrate 40, of one or more of the first surface structure functions can be modulated, at least pseudo-randomly between certain limits along the length, l , of the substrate 40. In yet another example, the peak angle of the first surface structure function can be modulated along the length l of the substrate 40. Thus, a combination of modulation techniques can be used to create the three-dimensional surface of the substrate 40 so that the single three-dimensional surface turns and diffuses light. The specific modulation techniques used to produce the substrate 40 depicted in Figure 2 will be described in greater detail below.

Figure 5 is a graphical representation showing three cross-sections of a substrate 40 in different positions along the length " l " of Figure 2. A first cross-section 50, taken at, for instance, the position of 400 microns along the " l " direction of Figure 2, could extend for a portion of the width w of the substrate 40 (specifically, between about 200 and 500 microns in the " w " direction). The second cross-section 52 could be taken, for example, at the position of 800 microns along the " l " direction of Figure 2, and the third cross-section 54 could be taken, for example, at the position of about 1400 microns along the " l " direction in Figure 2. The vertical axis in Figure 5 is meant to show only an amount of variation in the height of the surface of substrate 40 and not the actual height of the substrate 40. The horizontal axis in Figure 5 shows the horizontal position along the w direction in Figure 2. As can be seen in the cross-sections of Figure 5, modulated sawtooth functions continue to exist at specific cross-sections 50, 52, and 54 of the substrate 40. Because the phase of these structures has been modulated, however, each cross-section 50, 52, 54 has peaks 56 that are not in alignment with the other cross-sections 50, 52, 54. This is also evident from the top view of Figure 2, in which the modulated surface functions 46 extending the length l of the substrate 40, tend to sway, turn, combine or bifurcate, and cross in such a way that there are no discrete elements. In Figure 5, the peak angles 58 of the sawtooth functions are about 90 degrees. Although Figure 5 does not show modulated peak angles of the sawtooth functions, these peak angles could also vary from one peak to the next along the generally longitudinal direction " l " of Figure 2 for a given optical

element 46. The peak is the local height maxima on the resultant surface cross section in the w direction.

Even after the first surface structure function is modulated to produce the three-dimensional surface of the substrate 40, the characteristics of the first surface structure function that produce output specular components from input beams of light are largely retained in the resulting three-dimensional surface. The amount of specular behavior, or light turning behavior, is tunable by altering the amplitude and/or spatial frequency modulation applied to the first surface structure function. For instance, reducing the amount of modulation applied to the first surface structure function increases specular behavior. In contrast, an increase in the amount of modulation applied to the first surface structure function decreases specular behavior, but increases diffusion. Similarly, a reduction in the amount of modulation applied to the first surface structure function also decreases the diffuse behavior of the substrate, and an increase in the amount of modulation applied to the first surface structure function increases the diffuse behavior of the substrate.

Figure 6 shows the turning and diffusing properties of an exemplary embodiment of an optical substrate 100 that can be used for brightness enhancement applications. For clarity in Figure 6, the irregular three-dimensional surface 41 of Figure 2 is not shown, but would be present if shown as light-exiting surface 102 with characteristic surface dimensions of from about 100 mm to about 1 nm. A first beam of light, 138, having a zero degree angle of incidence, θ , to the substrate 100 is directed back by the light-exiting surface 102 toward the input. The light is not only directed back, but it is diffused so that, instead of a single output beam being formed, there is a first diffusion ellipse formed by rays 136 and 134. Diffused light can, for instance, exist within the ellipse formed by rays 136 and 134 so that a solid ellipse is formed. A second input beam of light, 124 having an input angle of incidence of θ is directed by the substrate 100 so that it is transmitted through to the light-exiting surface 102 as exit beam 128 and is turned so that it exits generally normal to the substrate 100. Beam 128 is also diffused by light-exiting surface 102 so that a second diffusion ellipse is formed. The second diffusion ellipse is formed by the power half angle Φ between 128 and rays

130 or 132. The power half angle Φ , which can be used as one measure of the diffusion characteristics of the substrate 100, can vary between about 0.1 and 60 degrees. In other embodiments, by altering the type and/or amount of modulation, the power half angle Φ can be between about 1 and 5 degrees. Figure 6 shows that at least one output beam 130, 132 of light is turned by the substrate 100 and deviates from its input angle of incidence θ .

The diffusion characteristics of the substrate 100 of Figure 6 can vary widely. For example, the diffusion ellipses formed can be symmetric cones in one embodiment. In other embodiments, the diffusion can have no symmetry at all or can have very little symmetry. The random modulation can be controlled to effect diffusion in the w and l directions differently i.e., the amplitude, bandwidth and the modulation parameter is applied to can be one dimensional along either the w or l direction, or two dimensional with different parameters along w , l . Other coordinates could be used to change the orientation of the modulation function with respect to the first surface function, including other rotated or shifted Cartesian geometries, such as cylindrical, spherical or generally warped coordinate systems. These may be used when an asymmetric light pattern is desired.

The light directing characteristics of the substrate can also vary widely. Referring to Figure 7, if used with a light guide 106 of a backlighting unit having a lamp 108 and lower reflective surface 109, substrates 112 and 114 can increase brightness substantially, while also diffusing light. In brightness enhancement embodiments, the substrates 112 and 114 can increase brightness as viewed on-axis by about 30 percent to about 300 percent. Prior art linear prism arrays as well as brightness enhancement films with randomized prism arrays, cannot be used, or it is undesirable to use such arrays, in parallel because of Moiré effects. With this invention two substrates can be used at any angle with respect to one another between crossed (orthogonal) and parallel, because of the lack of Moiré effects. This allows for greater flexibility in the light output pattern. In other embodiments, the substrate increases on-axis brightness by at least 50 percent and by perhaps as much as about 200 percent. In brightness enhancement embodiments, the two substrates 112, 114 can be arranged to be

orthogonal to one another in order to turn and diffuse input beams of light from different directions. Because diffusion behavior is built into the substrates 112, 114, separate diffusion substrates need not be used to eliminate Moiré artifacts caused by the substrates 112, 114, although a diffusion substrate can be used within the scope of the invention for other reasons.

Prior art Figure 7 shows diffusers 116, 118. Diffuser 118 diffuses Moiré artifacts resulting from interference caused by any inherent regularity of substrates 112, 114. Diffuser 116 diffuses Moiré artifacts due to the regularity of an extractor pattern on the underside 120 of light guide 106 and the regularity of LCD panel 122. Conventional brightness enhancement films 112, 114 can be replaced with the current invention possibly eliminating thereby diffusers 118 and 116.

The diffusion characteristics of the substrates 112, 114 reduce or eliminate Moiré artifacts caused by many common light directing films, such as that shown in Figure 1. Exemplary films incorporating these substrates, therefore, can turn and diffuse light on one surface so that Moiré artifacts are reduced or eliminated.

The autocorrelation function, $R(x,y)$, is a measure of the randomness of a surface that is used in surface metrology. Over a certain correlation length, l_c , however, the value of an autocorrelation function, $R(x,y)$, drops to a fraction of its initial value. An autocorrelation value of 1.0, for instance, would be considered a highly or perfectly correlated surface. The correlation length, l_c , is the length at which the value of the autocorrelation function is a certain fraction of its initial value. Typically, the correlation length is based upon a value of $1/e$, or about 37 percent of the initial value of the autocorrelation function. A larger correlation length means that the surface is less random than a surface with a smaller correlation length. A more detailed discussion of the autocorrelation function is provided in David J. Whitehouse, Handbook of Surface Metrology, IOP Publishing Ltd. (1994), p. 49-58.

In some embodiments of the invention, the value of the autocorrelation function for the three-dimensional surface of the optical substrate 100 drops to less than or equal to $1/e$ of its initial value in a correlation length of about 1 cm or less. In still other

embodiments, the value of the autocorrelation function drops to $1/e$ of its initial value in about 0.5 cm or less. For the embodiment of the substrate 40, 100 shown in Figures 2 and 6, the value of the autocorrelation function along the length l drops to less than or equal to $1/e$ of its initial value in about 200 microns or less. For the same embodiment of Figures 2 and 6, the value of the autocorrelation function along the width w drops to less than or equal to $1/e$ of its initial value in about 11 microns or less.

The correlation length is related to the reduction of Moiré artifacts. As noted, smaller correlation length indicates a more random surface than a larger correlation length, and this smaller correlation length also relates to greater diffusion and the reduction of Moiré artifacts. Because the three-dimensional surface of the substrates 40, 100 are highly irregular, as indicated by the low correlation length, the substrates 40, 100 can be effective to reduce Moiré artifacts.

The following discussion is intended to provide some illustration of the anti Moiré properties of the present invention. In the following examples it will be shown that 1) the invention has much lower auto correlation than both straight prisms and randomized prism structures 2) auto correlation length is a good indicator as to the possibility that a structure will produce Moiré patterns in a system.

Consider the 20 um tall, 40 um pitch straight prism array 400 of Figure 18 as a baseline. The auto-correlation function 402 of a horizontal profile taken through the prism structure 400 along the w direction is shown in Figure 19. The attenuation of the auto correlation function 402 is an indicator of the randomness of the structure. The structure in Figure 18 is completely ordered and therefore the only attenuation is due to the finite extent of the sample. We must consider this roll off of the envelope of the sinusoidal auto correlation function when comparing to other examples.

Figure 20 shows a Moiré map 404. For the prism structure 400 of Figure 18, the Moiré map in Figure 20, is the image produced by multiplying the height (although, it doesn't have to be height that is modulated) maps of the structure of Figure 18 by that of a reference prism structure of similar pitch. This is similar to what happens when

two structures are placed in closed proximity in an optical system (or one is imaged onto another). The reference prism structure is a 50 μm pitch prism array oriented parallel to that of the prism structure 400 of Figure 18. This is the worst-case scenario for introducing Moiré.

A Moiré plot is shown in Figure 21 at 406. This is a profile of the Moiré map 404 of Figure 20 along the w direction. Note that for the 40 μm pitch prism of Figure 18, the Moiré map of Figure 20 and the Moiré plot of Figure 21 both show a strong beat pattern as a low frequency envelope.

Next consider the 40 μm pitch prism array of Figure 18 with $\pm 20\%$ randomness introduced into the horizontal position (w direction) of the prism centers resulting in random variations along each prism in the vertical, or l direction as shown at 408 in Figure 22.

Note now in Figure 23, the somewhat more rapid attenuation of the auto correlation. This is due to the introduction of the randomness to the prism 40 μm pitch prism array. In the Moiré map 412 of Figure 24 and the profile 414 thereof in Figure 25, the beat pattern is somewhat scrambled but still visible. As in Figure 19, the attenuation of the autocorrelation in Figure 23 is due to the finite extent of the sample.

Consider next one embodiment of the present invention as shown at 416 in Figure 26. This structure has full cycle (e.g., greater than 100% of the “pitch”) randomization along with superimposed phase modulated “prism wave forms” with heights between 20 μm and 10 μm and slopes between 40 and 50 degrees. In this case that randomness and superposition used results in bifurcating (or splitting) and merging structures or elements.

Note that, as shown in Figure 27, the auto-correlation function of a profile 418 of Figure 26 drops very rapidly compared to those of Figures 19 and 23 (e.g., to less than 0.2 in under 100 μm). Thus, it should be expected that the anti Moiré performance of Figure 26 is better than in Figures 18 and 22. This is shown at 420 and 422 in Figures 28 and 29. The beat frequency is entirely absent and all that remains is areas of non-

uniformity. As seen in Figure 29, these small non-uniformities are associated with the local structure of the invention and not the result of a beat pattern. The consequence of this is illustrated in Figures 30, 31 and 32. Here the Moiré maps are produced by using a 44 μm pitch reference prism array. Note that for the straight prism of Figure 18 and the 20% randomized prism of Figure 22, the beat pattern is at a lower spatial frequency (fewer cycles across the map).

In contrast the non-uniformities for the map of Figure 26 are similar to those in Figure 24. Since the non-uniformities are always on the same scale as the structure, they will not be visible in the display and are of no concern (if the design pitch is fine enough). Moiré in the former examples is far more problematic because the beat pattern can have a period that is a large multiple of the prism pitch and may result in easily visible artifacts.

In Figure 33 the vertical (l direction) auto correlation 430 of Figure 26 is shown. Here it is seen that the roll-off is much less than that of Figure 27, due to the longer period of the modulation in the vertical direction. In this example the vertical modulation is set so that the period of the oscillations is between 300 μm and 500 μm . For the Prism Array of Figure 22, the vertical modulation is set so that the period of the oscillations (run lengths) are between 10 μm and 100 μm . In this case the attenuation is faster than that of Figure 31 (see 432 in Figure 34).

The generation of a model for the surface of exemplary substrates will now be described in detail. It should be noted that a number of methods for the generation of a surface model can be used and that the following discussion is but one of these methods.

By way of example, the surface depicted in Figure 2 can be generated using an iterative process of superimposition of randomly, or psuedo-randomly, modulated waveforms. In Figure 2, a series of superimposed waveforms generally form the three-dimensional surface of the film. These “waveforms” in the resultant structure of Figure 2 are not necessarily present as distinct waveforms, however. Instead, the

resultant three-dimensional surface of Figure 2 contains superimposed waveforms that cross over each other and/or combine into a single waveform at certain locations.

To begin the iterative process that generates a substrate 40, such as that shown in Figure 2, a series of waveforms is defined. Each of the defined waveforms has the general cross sectional shape of a sawtooth with a height of about 20 micron (um) above a reference plane. This series of waveforms is the first surface structure function referred to above. Each waveform has geometrical properties to turn light. Each of the waveforms is modulated, as described earlier, in one or more of frequency, phase, peak angle (or height). For example, Figure 8 shows a single waveform 140 that extends from one end to the other along the l direction of Figure 2. This waveform 140 has been modulated in phase so that, as viewed in Figure 8, the horizontal position of the peak of the waveform varies between -20 and $+20$ microns in the w direction from a center position 142. Figure 9 shows the variation in phase of the waveform 140 as a function of position along the direction l of Figure 8. In the embodiment of Figures 8 and 9, modulation is applied to the waveform in random intervals between about 300 and 500 microns along the length, l , of the waveform so that the phase of the peak changes every 300 to 500 microns as l varies.

The peak angle is the angle formed at the peak of a waveform and is shown in Figure 5 as numeral 58. For the waveform of Figure 8, the peak angle has also been modulated every 300 to 500 microns along l between 90 degrees and 92.8 degrees. Figure 10 shows the variation in the peak angle of the waveform of Figure 8 along the length l . The height of each waveform may also be modulated randomly between 15 and 20 microns along the length l .

Although only the phase and peak angle have been randomly modulated in the waveform shown in Figure 8, the frequency and height can also be modulated in other embodiments. For instance, in one embodiment, the height of a single waveform could be randomly modulated along the length l . In another embodiment, the frequency of a single waveform could be randomly modulated along the length l . Thus, the waveform is thin in some locations and thicker in other locations. In still

other embodiments, the height of different waveforms can be modulated differently. Thus, a variety of phase, frequency, peak angle and height modulation techniques can be used within the scope of the invention to form the three-dimensional surface structure of the substrates 40, 100. The amount of modulation can also vary widely in the in the various techniques.

To form the structure shown in Figure 2, a first iteration of superimposition of waveforms is performed. In the depicted embodiment, each individual waveform (modulated as described above) is stepped or placed on the surface of the substrate 40, 100 at about 40 micron intervals along the width w of the substrate 40, 100. For the 2,000 micron wide surface shown in Figure 2, fifty waveforms would be superimposed at about 40 micron intervals. The resulting surface structure model after this first iteration would appear as shown in Figure 11.

A second iteration of the superimposition of modulated waveforms is then performed. This second iteration can be performed in a similar manner as the first iteration. For example, another series of waveforms can be created as described above and can be superimposed at about 40 micron intervals along the width w of the substrate. The resulting surface structure model is shown in Figure 12.

Though not necessary, to form the surface structure model shown in Figure 2 from that shown in Figure 12, a third iteration can be performed in which a sawtooth function is superimposed. The sawtooth function may have an 8 micron height and be superimposed at 20 micron intervals along the width w of the film. This third iteration, which makes up a small portion of the resultant surface height map, can be used primarily to fill flat spots on the surface. The resulting three-dimensional surface has a random or pseudo-random structure in which the individual waveforms have been superimposed to form the surface. Due to the iterated method of superposition and the large height of the random phase modulating function the surface does not contain individual optical elements. Instead, the resultant surface is an integrated optical substrate that is formed by the convergence of multiple modulations and superimpositions by Boolean union.

Referring to Figures 14, 15 and 16, the method by which the substrate is randomized will now be explained. A first window 216 is defined in a coordinate system. Locations of control points 202, 204 are randomized to form a modulation path 206 in a second window 200. The second window 200 is wider than the cross section of a surface function 208, e.g., three times the width of the surface function 208. The surface function may be for example a sawtooth function or a triangular function. Starting with a first control point 202 at the top of the second window 200, at each control point location the following elements are randomized: the x position of the control point within a predetermined range such as ± 20 μm ; the y distance to the next control point within a predetermined range such as from 300 μm to 500 μm ; the height of the surface function, e.g., either 0 μm or 20 μm .

The randomized control point locations 202, 204 are quantized to a predetermined interval such as 20 μm in order to reduce diffraction effects. New control points are randomly added to the second window 200 along the modulation path 206 until the length of the second window 200 in the y (or l) direction is exceeded. However, the first control point 202, 204 falling outside of the second window 200 is retained.

The modulation path 206 is determined from the control points 202, 204 for example by using a combination of nearest neighbor or linear or cubic interpolation. Discontinuities along the modulation path 206 are introduced between any two consecutive control points 202 having a nonzero height when a control point 204 having zero height lies between the two consecutive control points 202 having a nonzero height.

A nonzero surface function 208 is generated along the modulation path between successive control points 202 having a nonzero height. The surface function 208 assumes a value of zero between control points 202 having a nonzero height when a control point 204 having zero height lies between the two consecutive control points 202 having a nonzero height. The surface function 208 may have for example a cross sectional profile of a saw tooth function.

The window 200, containing the randomized surface function 208 is aligned and overlaid at a first position with a master function 210, which is initially zero. A Boolean union operation is performed between the surface function 208 within the window 200 and the master function 210. This results in the surface function 208 on the master function 210. The window 200 is moved left to right along the master function 210 in a predetermined incremental step of for example 40 μm . A new surface function 208 is now randomly generated within the window 200 in the manner described above and a Boolean union operation is performed between the new surface function 208 and the master function 210. The window is again moved the predetermined incremental step, a yet newer surface function 208 is again randomly generated within the window in the manner described above and yet a new Boolean union operation is performed between the newer first function 208 and the master function 210. This randomization, Boolean union and stepping process is repeated over the entire width of the master function 210. At the end of the master function 210, the window returns to the first position and the randomization, Boolean union and stepping process is repeated any number of times over the entire width of the master function 210 resulting the randomized substrate 152 of Figure 13.

The surface function is a triangle with a width of approximately 40 μm and a height of between 1 μm and 200 μm or more particularly a width of approximately 40 μm and a height of approximately 18 μm . The surface function may also be a triangle with a base to height ratio of between 40 to 1 and 1 to 10 or more particularly with a base to height ratio approximately 40 to 18.

Holes or areas of zero height in the randomized substrate are found using morphologic operators and a "skeleton mask" function is created (Fig. 40). This function is convolved with the surface function 208 and the result is combined by Boolean union with the master function 210. These sights or areas can also be use to create a sparse pattern of anti-wet-out (or Newton's rings) bumps or protrusions that have a height that is greater than the rest of the pattern. These bumps do not need to have the same form or function as the bulk of the surface. The final pattern 212 is taken by trimming away at least the outer 100 μm from the master function 210. In

Figure 22, multiple copies of the final pattern 212 are then placed side-by-side to one another, or “tiled”, so as to create a substrate surface as a two dimensional array on a wafer 214 mirrored with respect to one another for first order continuity. The size of the tiles, i.e., the master, is larger than the correlation length of the resultant pattern.

Thus, in Figure 16, a window is defined at 302 and points are randomly selected within the window 304 thereby creating a modulation path 306 connecting the randomly selected points. Heights are randomly assigned at 308 to the randomly selected points within the window. A master function is defined at 314 and a surface function is generated along the modulation path at 310 and repeatedly combined with a master function 312 at successive locations within the master function.

As best understood the surface of the substrate may not only be randomized in height, frequency, phase or peak angle, but also by refractive index. Any of these parameters may also be modulated as shown in Figures 35 – 39. Therein, a sinusoidal carrier waveform $\sin(x)$ may be modulated in amplitude, phase, or frequency by a random function $r(x)$ yielding a randomized function $R(x)$ according to any of the following equations:

$$R(x) = r(x) + \sin(x/k)(1)$$

$$R(x) = \sin(x/k + c \times r(x))(2)$$

$$R(x) = \sin(x/(k + c \times r(x)))(3)$$

$$R(x) = \text{sawtooth}(x^2/(n + 10 r(x))) \times (n)/(x+n)(4)$$

$$R(x) = r'(x) + \text{sawtooth}(x^2/(k + m \times r(x))) \times (n)/(x+n)(5)$$

where $r'(x)$ is a second random function (or third surface function) and c , k and n are constants. The sawtooth function generates a sawtooth wave as a function of time, t , or space, w , l , having a period of 2π . The sawtooth creates a wave similar to $\sin(t, w, l)$ having peaks of -1 and 1 . The sawtooth wave is defined to be -1 at multiples of 2π and to increase linearly with time with a slope of $1/\pi$ at all other times. Generally a

plurality of random functions may be used to modulate a plurality of parameters of the first surface function. The plurality of random functions, $r(x)$, as seen in Figure 39 may each be spatially constant or spatially varying, or any combination thereof.

The actual surface of the substrates, having characteristic dimensions of about 100 nm to 1 nm, can be generated in accordance with a number of processing techniques. These processing techniques include photolithography, gray-scale lithography, microlithography, electrical discharge machining and micromachining using hard tools to form molds or the like for the surface model described above.

For example, the method of making the substrates may be by mastering, electroforming and mold forming. Photolithographic Mastering may be used to direct laser write to a photoresist, a gray scale mask or a series of halftone masks that may be tiled. The photoresist may be directly removed by the laser photons or used as a precursor to an additional process step, such as reactive ion etching (RIE). Alternatively the geometry might be mastered using hard tools, such as a single point diamond tool on a five axis mill. The master will generally be made as a negative. The Substrate of the master may be glass, including fused silica, crystalline, metal or plastic (polycarbonate for example). The master may be used to mold plastic parts directly or used in electroforming.

Electroforming is in one or two stages. The master will be a positive if only one stage is used. The master may be coated with a thin metal coating (especially if the master is not conductive to begin with). A "father" electroform is created by electrodepositing nickel on the master. This replica is again electroformed to create a "daughter" that is used to mold the plastic parts.

The object that is used to mold the device (films) is referred to as the mold. The mold may be in the form of a belt, a drum, a plate, or a cavity. The mold may be tiled from a plurality of masters or electro forms. The mold may be used to form the structures on a substrate through hot embossing of the substrate, cold calendaring of the substrate or through the addition of an ultraviolet curing or thermal setting material in which the structures are formed. The mold may be used to form the film through

injection molding or vacuum forming. The substrate or coating material may be any organic, inorganic or hybrid optically transparent material and may include suspended diffusion, birefringent or index of refraction modifying particles.

The optical substrate so formed may be formed with an optically transparent material with an index of refraction between of 1.1 and 3.0 and more particularly with an index of refraction of approximately 1.75.

In Figure 41 a sectional view of a backlight display 500 device is shown. The backlight display device 500 comprises an optical source 502 for generating light 504. A light guide 506 guides the light 504 therealong. A reflective surface 508 reflects the light 504 out of the light guide 506. At least one optical substrate 510 is receptive of the light 504 from the reflective surface 510. The optical substrates 510 comprise a three-dimensional surface 512 defined by two surface structure functions, the first surface structure function has a length, width and peak angle with optical characteristics to produce at least one output specular component from an input beam of light. The second surface structure function has a geometry with at least pseudo-random characteristics to modulate the first surface structure function in one or more of frequency, phase and peak angle along the length of the first surface structure function. The three-dimensional surface 512 has a correlation function value of less than about 37 percent of an initial in a correlation length of about 1 cm or less. In the backlight display device 500, one of the optical substrates 510 may include a first three-dimensional surface 512 and a second three-dimensional surface 514 opposing the first three-dimensional surface 512. The second three-dimensional surface 514 may also have a correlation function value of less than about 37 percent of an initial in a correlation length of about 1 cm or less. The second three-dimensional surface has two surface structure functions; a third surface structure function having a length, width and peak angle with optical characteristics to produce at least one output specular component from an input beam of light and a fourth surface structure function having a geometry with at least pseudo-random characteristics to modulate the first surface structure function in one or more of frequency, phase and peak angle along the length of the first surface structure function.

In the backlight display device 500 the optical substrates 510 include first and second surface functions in a relative orientation from zero to ninety degrees with respect to one another, which may be parallel or perpendicular with respect to one another.

Aside from the use of the optical substrates described above in backlight displays for brightness enhancement, the substrates can be used in a wide variety of other applications as well. Embodiments of the substrates can be used in Fresnel lenses, holographic substrates or in combination with conventional lenses, prisms or mirrors. Such embodiments could be formed by modulating concentric circles or ellipses having fixed characteristics. The optical substrates can also be used in single or multi-order reflective, transmissive or partially transmissive, whether light absorbing or non light absorbing prisms, holographic optical elements, or diffraction gratings, and the output angles of the specular components can be tuned by changing the first surface structure function. The substrates can be used in other applications such as projection displays, illuminated signs, and traffic signals.

In the present discussion specular is defined to mean any component of reflected or transmitted light that is not diffused on a macroscopic scale. The macroscopic is the bulk behavior that would be observed by interrogating the surface of the substrate with a beam of coherent light with a diameter of about 500 micron or greater. A classic multi-order grating would be considered to have multiple specular components.

Any references to front and back, right and left, top and bottom, upper and lower, and horizontal and vertical are, unless noted otherwise, intended for convenience of description, not to limit the present invention or its components to any one positional or spatial orientation. All dimensions of the components in the attached Figures can vary with a potential design and the intended use of an embodiment without departing from the scope of the invention.

While the invention has been described with reference to several embodiments thereof, it will be understood by those skilled in the art that various changes may be made and equivalents may be substituted for elements thereof without departing from

the scope of the invention. In addition, many modifications may be made to adapt a particular situation or material to the teachings of the invention without departing from the essential scope thereof. Therefore, it is intended that the invention not be limited to the particular embodiments disclosed as the best mode contemplated for carrying out this invention, but that the invention will include all embodiments falling within the scope of the appended claims.

CLAIMS

What is claimed is:

1. A method of modeling a surface of an optical substrate 100, the method comprising:

defining a first window 216 in a coordinate system;

defining a master function 210 within the first window 216;

defining a second window 200 as a segment of the first window 216 at a first location within the first window 216;

selecting a set of points within the second window 200;

defining a modulation path 206 interconnecting the selected set of points;

defining a surface function along the modulation path 206;

modulating the surface function along the modulation path 206;

combining the modulated surface function with the master function 210, generating thereby a three dimensional structural pattern over the extent of the modulation path 206.

2. The method as set forth in Claim 1 wherein selecting a set of points within the second window 200 includes randomly selecting a set of points within the second window 200.

3. The method as set forth in Claim 1 wherein modulating the surface function along the modulation path 206 includes randomly modulating the surface function along the modulation path 206.

4. The method as set forth in Claim 1 further comprising moving the second window 200 to a new location within the first window 216.

5. The method as set forth in Claim 4 further comprising repeating
- selecting a set of points within the second window 200;
- defining a modulation path 206 interconnecting the selected set of points;
- defining a surface function along the modulation path 206;
- modulating the surface function along the modulation path 206;
- combining the modulated surface function with the master function 210, generating thereby a three dimensional structural pattern over the extent of the modulation path 206 until the second window 200 has been coextensive with all of the points in the first window 216.
6. The method as set forth in Claim 5 further comprising:
- returning the second window 200 to the first location within the first window 216; and
- repeating selecting a set of points within the second window 200;
- defining a modulation path 206 interconnecting the selected set of points;
- defining a surface function along the modulation path 206;
- modulating the surface function along the modulation path 206;
- combining the modulated surface function with the master function 210, generating thereby a three dimensional structural pattern over the extent of the first window 216 until the second window 200 has been coextensive with all of the points in the first window 216.
7. The method as set forth in Claim 6 further comprising:
- generating a mask function 442 from a set of morphologic operators;
- convolving the mask function 442 with the surface function; and

performing the Boolean union of the convolution of the mask function 442 and the modulation function with the master function 210.

8. The method as set forth in Claim 1 wherein combining the modulated surface function with the master function 210 comprises performing the Boolean union of the modulated surface function with the master function 210.
9. The method as set forth in Claim 1 further comprising placing a plurality of three dimensional structural patterns generated over the extent of the first window 216 side-by-side with one another to form an array of three dimensional structural patterns.
10. An optical substrate 100 generated by the method as set forth in Claim 1.
11. The optical substrate 100 as set forth in Claim 10 having a correlation function value of $1/e$ within a prescribed distance from a first location within the three dimensional structural pattern in a first direction in the coordinate system.
12. The optical substrate 100 as set forth in Claim 11 wherein the correlation function is an auto correlation function.
13. The optical substrate 100 as set forth in Claim 11 wherein the correlation function is a cross correlation function.
14. The optical substrate 100 as set forth in Claim 11 having minimized Moiré patterns.
15. The method as set forth in Claim 1 wherein combining the modulated surface function with the master function 210 comprises performing a Boolean union of the modulated surface function with the master function 210.
16. An optical substrate 100, comprising:

a surface characterized by a correlation function value of less than about 37 percent of an initial value within a correlation length of about 1 cm or less, wherein the surface is defined by a first surface structure function 50, 52, 54 modulated by a second

function, the surface of the optical substrate 100 producing specular and diffuse light from a first input beam of light.

17. The optical substrate 100 as set forth in Claim 16, wherein the first surface structure function 50, 52, 54 extends a length from a first end to a second end of the substrate.

18. The optical substrate 100 as set forth in Claim 17, wherein the first surface structure function 50, 52, 54 has a sawtooth or triangular cross section.

19. The optical substrate 100 as set forth in Claim 16, wherein the surface of the optical substrate 100 comprises a shape that turns and diffuses light to form a plurality of diffusion ellipses each with a power half angle between about 0.1 and about 60 degrees.

20. The optical substrate 100 as set forth in Claim 19, wherein the power half angle is between about 1 and about 5 degrees.

21. The optical substrate 100 as set forth in Claim 19, wherein a first input beam of light has a first angle of incidence and the surface of the optical substrate 100 is shaped so that the first input beam of light is transmitted through the optical substrate 100 and turned by the surface of the optical substrate 100 to an output angle different from the first angle of incidence.

22. The optical substrate 100 as set forth in Claim 21, wherein the output angles of the specular components are determined by the first surface structure function 50, 52, 54.

23. The optical substrate 100 as set forth in Claim 22, wherein a second input beam of light normal to the optical substrate 100 is substantially reflected by the surface of the optical substrate 100 and forms output specular components with a power half angle between about 0.1 and about 60 degrees.

24. The optical substrate 100 as set forth in Claim 16, wherein the correlation length is about 200 microns or less.

25. A brightness enhancement film, comprising:

a surface characterized by a correlation length of about 1 cm or less, the surface having a shape to turn and diffuse incident light to produce at least a 30 percent brightness increase on-axis to a viewer, wherein the surface produces diffused components of light with a power half angle between about 0.1 and 60 degrees.

26. The film as set forth in Claim 25, wherein the surface is characterized by a correlation length of about 200 microns or less.

27. The film as set forth in Claim 25, wherein the brightness increase on-axis is about 30 percent to about 300 percent.

28. The film as set forth in Claim 25, wherein the brightness increase on-axis is about 50 percent to about 200 percent.

29. An optical substrate 100, comprising:

a surface defined by two surface structure functions, the first surface structure function 50, 52, 54 having a geometry with optical characteristics to produce at least one output specular component from an input beam of light;

the second surface structure function 144, 146 having a geometry with at least pseudo-random characteristics to modulate the first surface structure function 50, 52, 54;

wherein the three-dimensional surface has a correlation function value of less than about 37 percent of an initial in a correlation length of about 1 cm or less.

30. The optical substrate 100 as set forth in Claim 29, wherein the surface is characterized by a correlation length of about 200 microns or less.

31. The optical substrate 100 as set forth in Claim 29, wherein the first surface structure function 50, 52, 54 is characterized by a series of first surface structure functions 50, 52, 54, each first surface structure function 50, 52, 54 having a length, width and peak angle.
32. The optical substrate 100 as set forth in Claim 31, wherein the at least pseudo-random characteristics of the second surface structure function 144, 146 produce one or more of frequency, phase, and peak angle modulation of the first surface structure function 50, 52, 54.
33. The optical substrate 100 as set forth in Claim 32, wherein the phase modulation includes modulating a horizontal position of at least one of the first surface structure functions 50, 52, 54 along the length of that first surface structure function 50, 52, 54.
34. The optical substrate 100 as set forth in Claim 32, wherein the frequency modulation includes modulating the width of at least one of the first surface structure functions 50, 52, 54 along the length of that first surface structure function 50, 52, 54.
35. The optical substrate 100 as set forth in Claim 32, wherein the peak angle modulation includes modulating a peak angle of at least one of the first surface structure functions 50, 52, 54 along the length of that first surface structure function 50, 52, 54.
36. The optical substrate 100 as set forth in Claim 29, wherein the surface diffuses and turns the input beam of light to form a plurality of diffusion ellipses each with a power half angle between about 0.1 and about 60 degrees.
37. The optical substrate 100 as set forth in Claim 36, wherein the power half angle is between about 1 and about 5 degrees.
38. The optical substrate 100 as set forth in Claim 36, wherein the input beam of light has an angle of incidence and the surface is structured so that the input beam of light is transmitted through the optical substrate 100 and turned by the surface to form

output angles of the specular components that are different from the angle of incidence.

39. The optical substrate 100 as set forth in Claim 38, wherein the output angles of the specular components are determined by the first surface structure function 50, 52, 54.

40. A method for modeling a three-dimensional surface of an optical film, the method comprising:

modulating a plurality of first surface structure functions 50, 52, 54 to produce irregular, modulated waveforms;

placing a first set of the plurality of modulated waveforms at intervals on a work surface, each of the modulated waveforms of the first set being superimposed over adjacent modulated waveforms; and

placing a second set of the plurality of modulated waveforms at intervals on the work surface, the second set of modulated waveforms being superimposed over the first set of modulated waveforms.

41. The method as set forth in Claim 40, wherein the waveforms, prior to modulating, are shaped as sawtooth or triangular functions in cross section.

42. The method as set forth in Claim 41, wherein the plurality of sawtooth or triangular functions are modulated by one or more of phase, frequency, and peak angle modulation.

43. The optical substrate 100 as set forth in Claim 10 wherein the optical substrate 100 is generated by photolithography, gray-scale lithography, microlithography, electrical discharge machining or micromachining using hard tools to form molds.

44. The optical substrate 100 as set forth in Claim 43 wherein the optical substrate 100 includes a surface having characteristic dimensions from 100 mm to 1 nm.

45. A method of modeling a surface of an optical substrate 100, the method comprising:

- defining a first window 216 in a coordinate system;
- defining a master function 210 within the first window 216;
- defining a second window 200 at a first location within the first window 216;
- randomly selecting a set of points within the second window 200;
- defining a modulation path 206 interconnecting the selected set of points;
- defining a surface function along the modulation path 206;
- randomly modulating the surface function along the modulation path 206;
- combining the modulated surface function with the master function 210, generating thereby a three dimensional structural pattern over the extent of the modulation path 206;
- moving the second window 200 to a new location within the first window 216 and repeating
- selecting a set of points within the second window 200;
- defining a modulation path 206 interconnecting the selected set of points;
- defining a surface function along the modulation path 206;
- modulating the surface function along the modulation path 206; and
- combining the modulated surface function with the master function 210, generating thereby a three dimensional structural pattern over the extent of the modulation path 206 until the second window 200 has been coextensive with all of the points in the first window 216.

46. An optical substrate 100, comprising:

a surface characterized by a correlation function value of less than about 37 percent of an initial value within a correlation length of about 1 cm or less, wherein the surface is defined by a first surface structure function 50, 52, 54 having a sawtooth or triangular cross section extending a length from a first end to a second end of the substrate modulated by a second function, the surface of the optical substrate 100 producing specular and diffuse light from a first input beam of light.

47. A brightness enhancement film, comprising:

a surface characterized by a correlation length of about 1 cm or less, the surface having a shape to turn and diffuse incident light to produce a 50 percent to 200 percent brightness increase on-axis to a viewer, wherein the surface produces diffused components of light with a power half angle between about 0.1 and 60 degrees.

48. An optical substrate 100, comprising:

a surface defined by two surface structure functions, the first surface structure function 50, 52, 54 having a length, width and peak angle with optical characteristics to produce at least one output specular component from an input beam of light;

the second surface structure function 144, 146 having a geometry with at least pseudo-random characteristics to modulate the first surface structure function 50, 52, 54 in one or more of frequency, phase and peak angle along the length of the first surface structure function 50, 52, 54;

wherein the three-dimensional surface has a correlation function value of less than about 37 percent of an initial in a correlation length of about 1 cm or less.

49. A method for modeling a three-dimensional surface of an optical film, the method comprising:

modulating by one or more of phase, frequency, and peak angle a plurality of first surface structure functions 50, 52, 54 shaped in cross section as sawtooth or triangular functions to produce irregular, modulated waveforms;

placing a first set of the plurality of modulated waveforms at intervals on a work surface, each of the modulated waveforms of the first set being superimposed over adjacent modulated waveforms; and

placing a second set of the plurality of modulated waveforms at intervals on the work surface, the second set of modulated waveforms being superimposed over the first set of modulated waveforms.

50. A method of making an optical substrate 100 comprising a surface characterized by a correlation function value of less than about 37 percent of an initial value within a correlation length of about 1 cm or less, wherein the surface is defined by a first surface structure function 50, 52, 54 modulated by a second function, the surface of the optical substrate 100 producing specular and diffuse light from a first input beam of light, the method comprising:

photolithographically mastering the surface of the optical substrate 100 to a photoresist, a gray scale mask or a halftone mask; and

forming a mold of the surface of the optical substrate 100 from the master by hot embossing, cold calendaring, ultraviolet curing or thermal setting.

51. The method as set forth in Claim 50 further comprising:

electroforming the master with a metal coating forming thereby a parent electroform;

electroforming the parent electroform forming thereby a child electroform.

52. The method as set forth in Claim 51 wherein electroforming the parent and child electroforms includes electro-depositing nickel thereon.

53. The method as set forth in Claim 50 wherein the substrate comprises organic, inorganic or hybrid optically transparent material including suspended diffusion, birefringent or index or refraction modifying particles.
54. The method as set forth in Claim 50 wherein the master is a negative of the optical substrate 100.
55. The method as set forth in Claim 50 wherein the master comprises glass, crystalline metal or plastic.
56. A method of making an optical substrate 100 comprising a surface characterized by a correlation function value of less than about 37 percent of an initial value within a correlation length of about 1 cm or less, wherein the surface is defined by a first surface structure function 50, 52, 54 modulated by a second function, the surface of the optical substrate 100 producing specular and diffuse light from a first input beam of light, the method comprising:
- hard tool mastering the surface of the optical substrate 100; and
- forming a mold of the surface of the optical substrate 100 from the master by hot embossing, cold calendaring, ultraviolet curing or thermal setting.
57. A backlight display device 500 comprising:
- an optical source 502 for generating light;
- a light guide 506 for guiding the light therealong including a reflective surface 508 for reflecting the light out of the light guide 506;
- at least one optical substrate 510 receptive of the light from the reflective surface 508, the optical substrate 510 comprising:
- a three-dimensional surface defined by two surface structure functions, the first surface structure function 50, 52, 54 having a length, width and peak angle with

optical characteristics to produce at least one output specular component from an input beam of light;

the second surface structure function 144, 146 having a geometry with at least pseudo-random characteristics to modulate the first surface structure function 50, 52, 54 in one or more of frequency, phase and peak angle along the length of the first surface structure function 50, 52, 54;

wherein the three-dimensional surface has a correlation function value of less than about 37 percent of an initial in a correlation length of about 1 cm or less.

58. The backlight display device 500 as set forth in Claim 57 wherein the at least one optical substrate 510 comprises a plurality of optical substrates 510.

59. The backlight display device 500 as set forth in Claim 58 wherein the plurality of optical substrates 510 include first and second surface functions in a relative orientation from zero to ninety degrees with respect to one another.

60. The backlight display device 500 as set forth in Claim 59 wherein the relative orientation of the first and second surface functions is parallel or perpendicular with respect to one another.

61. A backlight display device 500 comprising:

an optical source 502 for generating light;

a light guide 506 for guiding the light therealong including a reflective surface 508 for reflecting the light out of the light guide 506; and

an optical substrate 510 receptive of the light from the reflective surface 508, the optical substrate 510 comprising:

a first three-dimensional surface defined by first and second surface structure functions 144, 146; the first surface structure function 50, 52, 54 having a length,

width and peak angle with optical characteristics to produce at least one output specular component from an input beam of light;

the second surface structure function 144, 146 having a geometry with at least pseudo-random characteristics to modulate the first surface structure function 50, 52, 54 in one or more of frequency, phase and peak angle along the length of the first surface structure function 50, 52, 54;

a second three-dimensional surface opposing the first three-dimensional surface and defined by two surface structure functions; the third surface structure function having a length, width and peak angle with optical characteristics to produce at least one output specular component from an input beam of light;

the fourth surface structure function having a geometry with at least pseudo-random characteristics to modulate the first surface structure function 50, 52, 54 in one or more of frequency, phase and peak angle along the length of the first surface structure function 50, 52, 54;

wherein the first and second three-dimensional surfaces have a correlation function value of less than about 37 percent of an initial in a correlation length of about 1 cm or less.

62. The backlight display device 500 as set forth in Claim 61 wherein the optical substrate 510 includes first and second surface functions in a relative orientation from zero to ninety degrees with respect to one another.

63. The backlight display device 500 as set forth in Claim 62 wherein the relative orientation of the first and second surface functions is parallel or perpendicular with respect to one another.

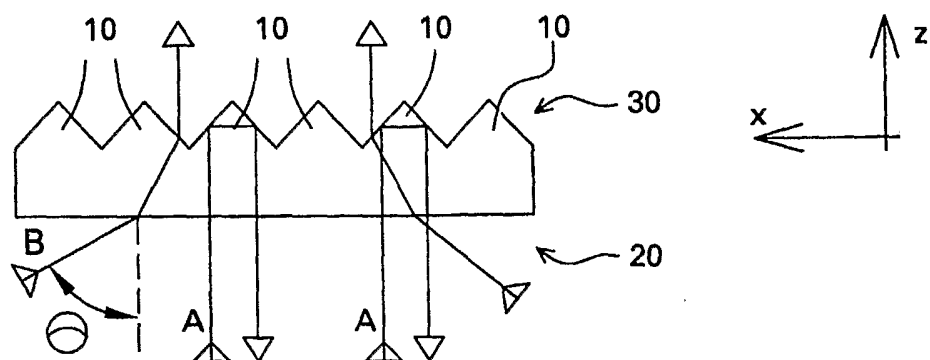
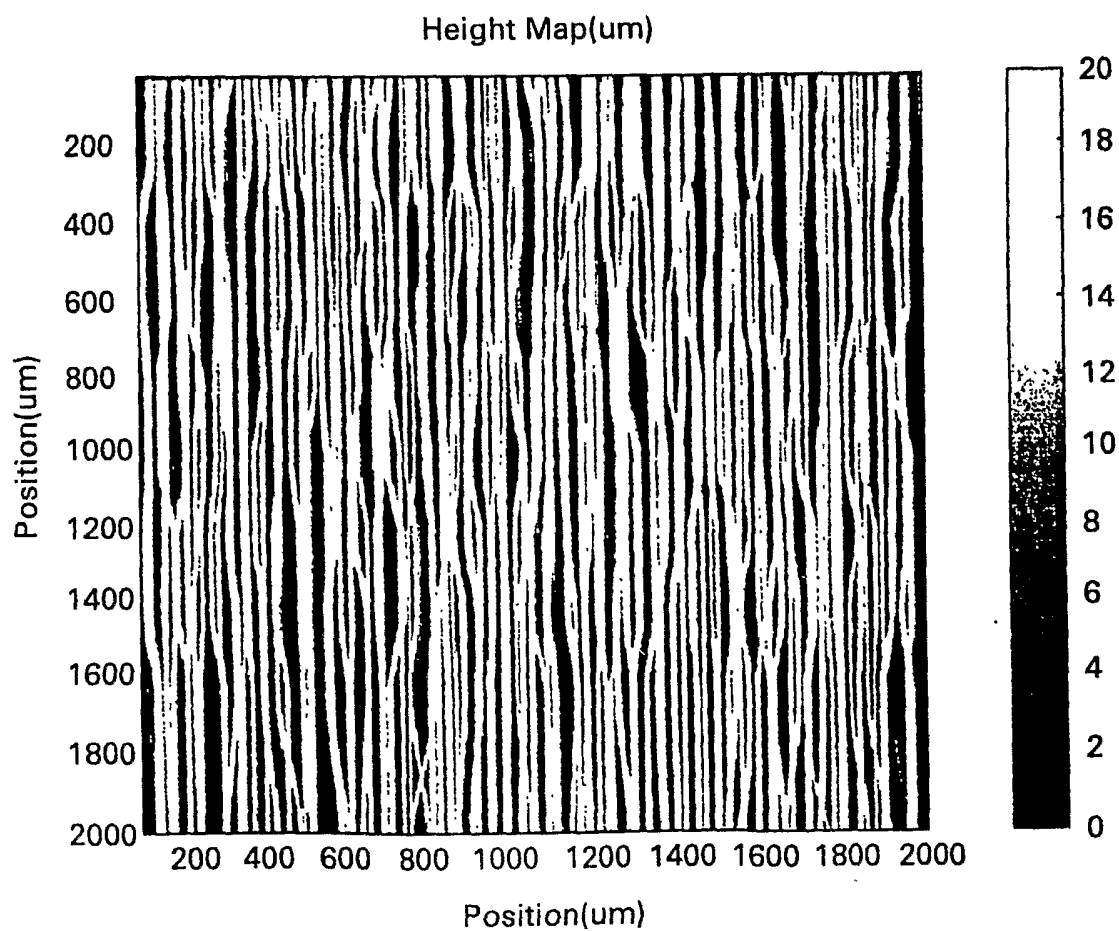
64. The optical substrate 100 as set forth in Claim 10 wherein the surface function is a triangle with a width of approximately 40 μm and a height of between 1 μm and 200 μm .

65. The optical substrate 100 as set forth in Claim 10 wherein the surface function is a triangle with a width of approximately 40 μm and a height of approximately 18 μm .
66. The optical substrate 100 as set forth in Claim 10 wherein the surface function is a triangle with a base to height ratio of between 40 to 1 and 1 to 10.
67. The optical substrate 100 as set forth in Claim 10 wherein the surface function is a triangle with a base to height ratio approximately 40 to 18.
68. The optical substrate 100 as set forth in Claim 10 wherein the surface of the optical substrate 100 is formed with an optically transparent material with an index of refraction between of 1.1 and 3.0.
69. The optical substrate 100 as set forth in Claim 10 wherein the surface of the optical substrate 100 is formed with an optically transparent material with an index of refraction of approximately 1.75.
70. The optical substrate 100 as set forth in Claim 65 wherein the surface of the optical substrate 100 is formed with an optically transparent material with an index of refraction of approximately 1.75.
71. The optical substrate 100 as set forth in Claim 61 wherein the second surface is optically smooth or planar.
72. The optical substrate 100 as set forth in Claim 61 wherein the second surface has a matte or diffuse finish.
73. The optical substrate 100 as set forth in Claim 72 wherein the second surface has diffusion characteristics that are anamorphic or anisotropic.
74. The optical substrate 100 as set forth in Claim 61 wherein the second surface is optically smooth or planar including a pattern of protrusions formed either in the substrate or attached with an adhesive.
75. An optical substrate 100, comprising:

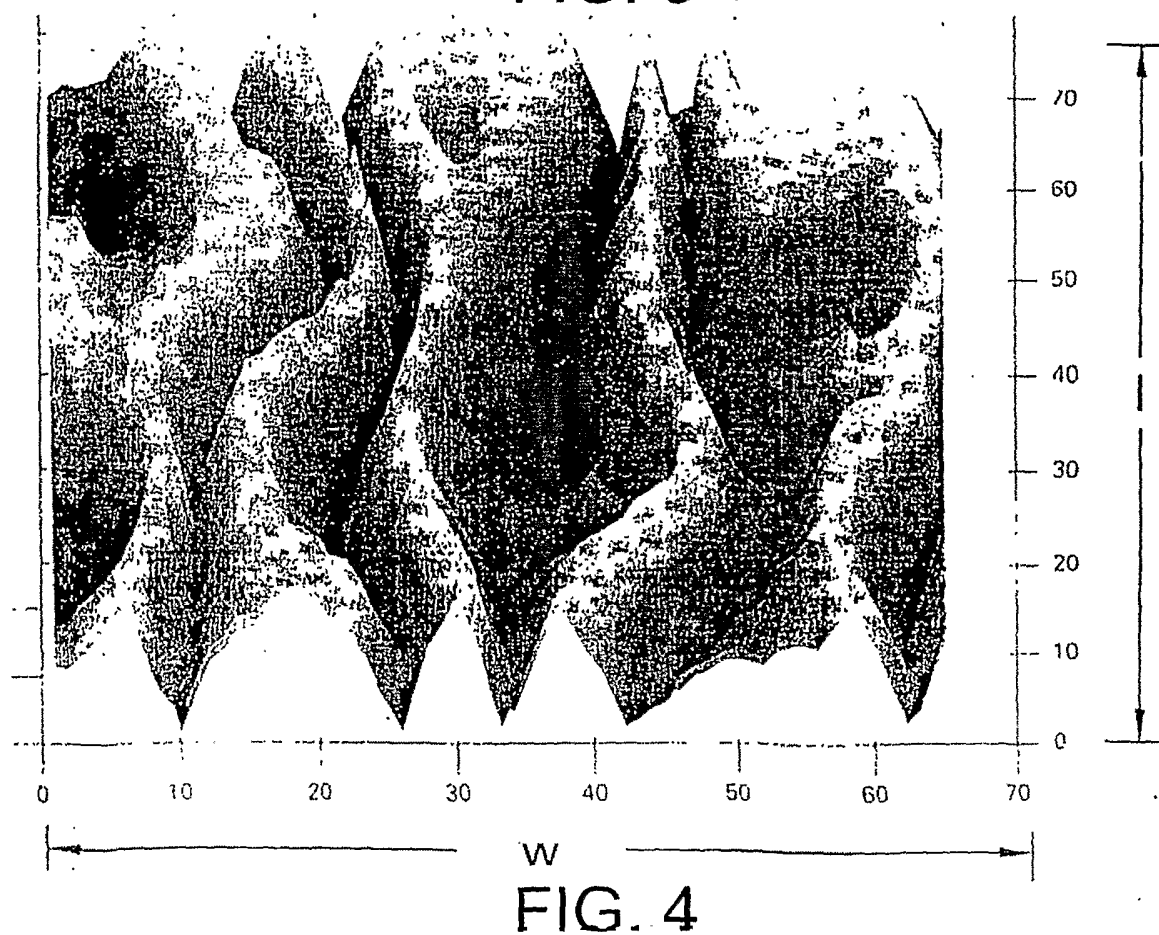
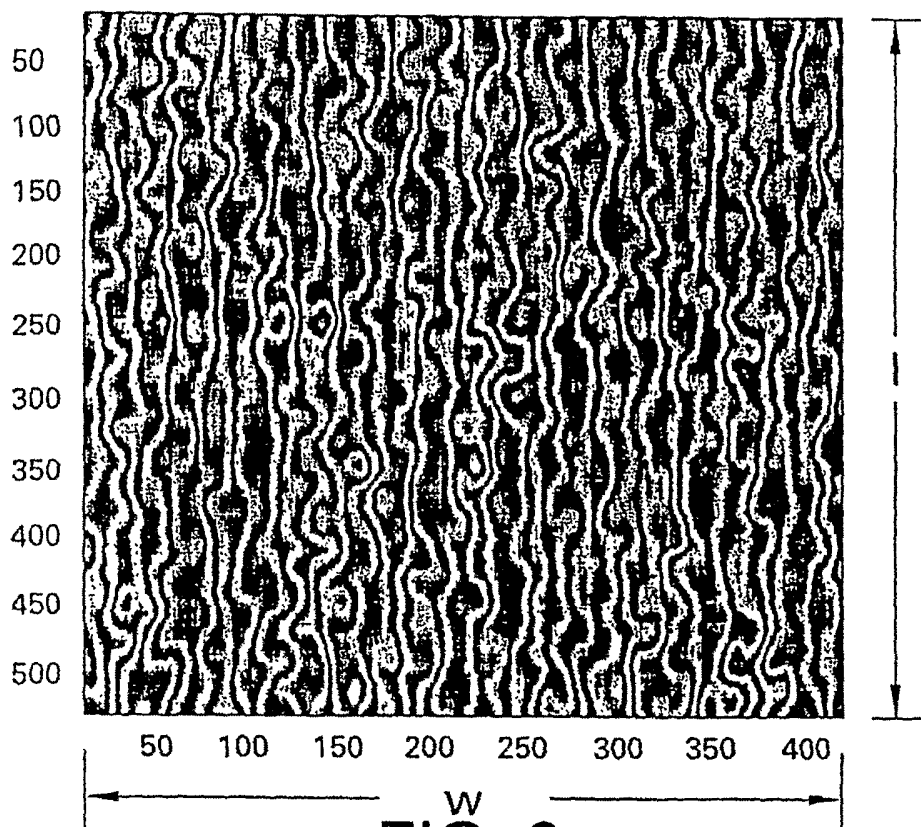
a surface characterized by a correlation function value of less than about 37 percent of an initial value within a correlation length of about 1 cm or less, wherein the surface is defined by a first surface structure function 50, 52, 54 having a plurality of parameters modulated by a plurality of random functions.

76. The optical substrate 100 as set forth in Claim 75 wherein the plurality of random functions are spatially constant or spatially varying.

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**FIG.1 (PRIOR ART)****FIG.2**

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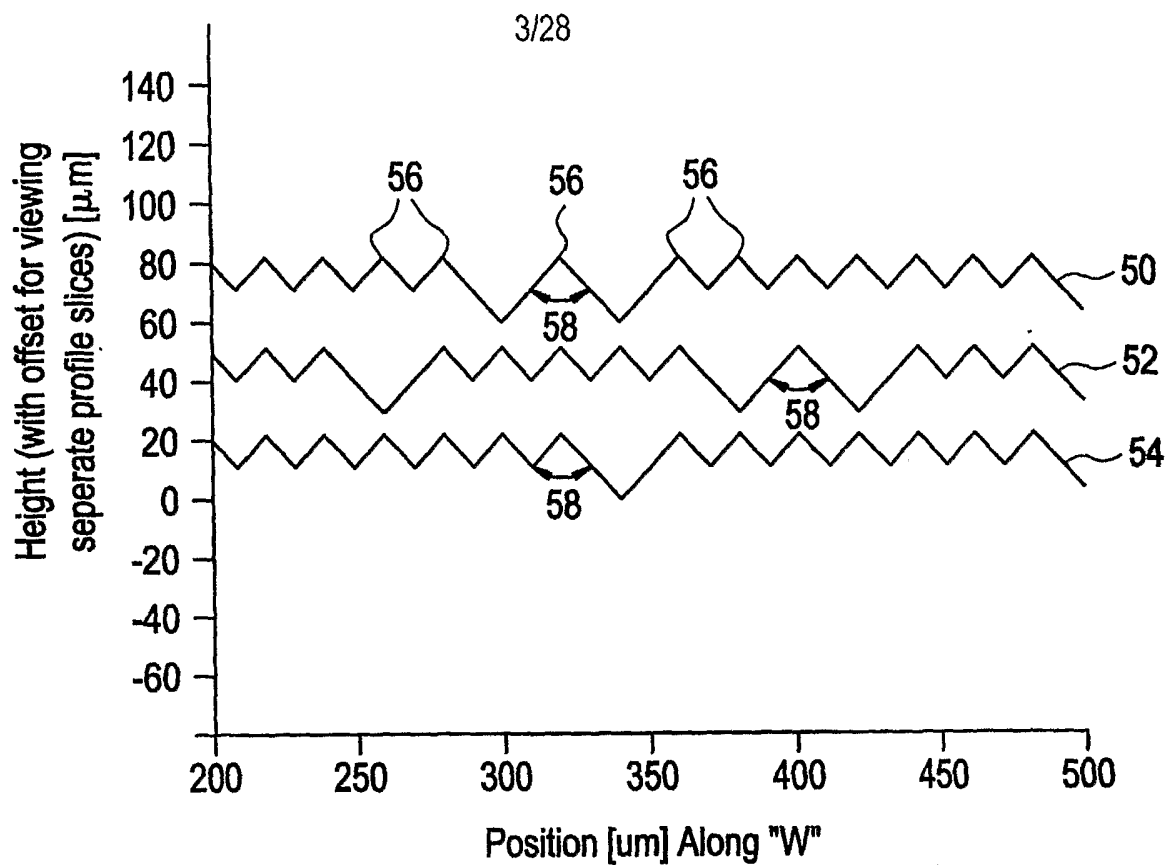


FIG. 5

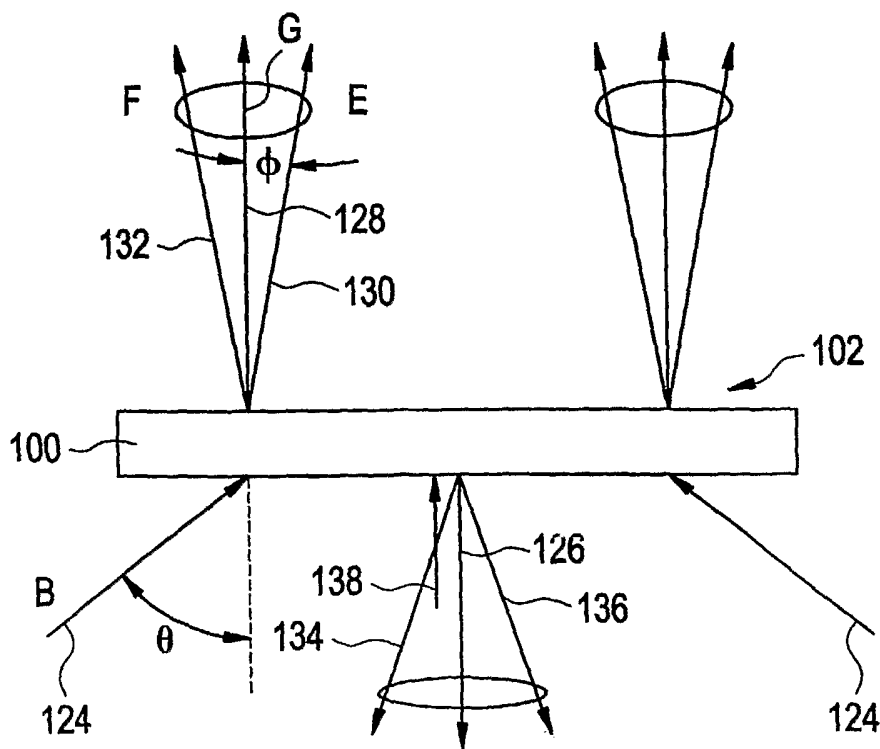


FIG. 6

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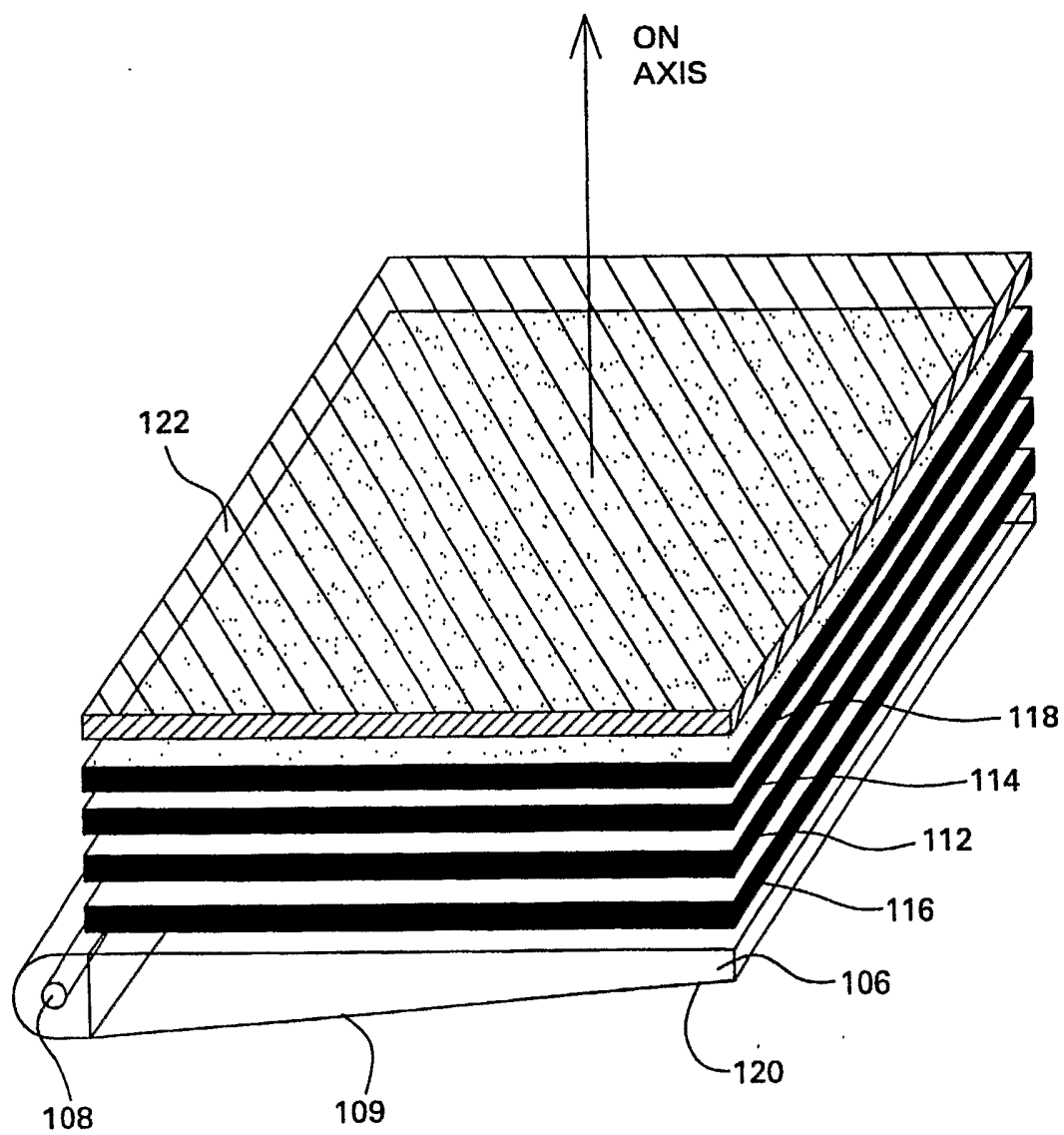


FIG. 7

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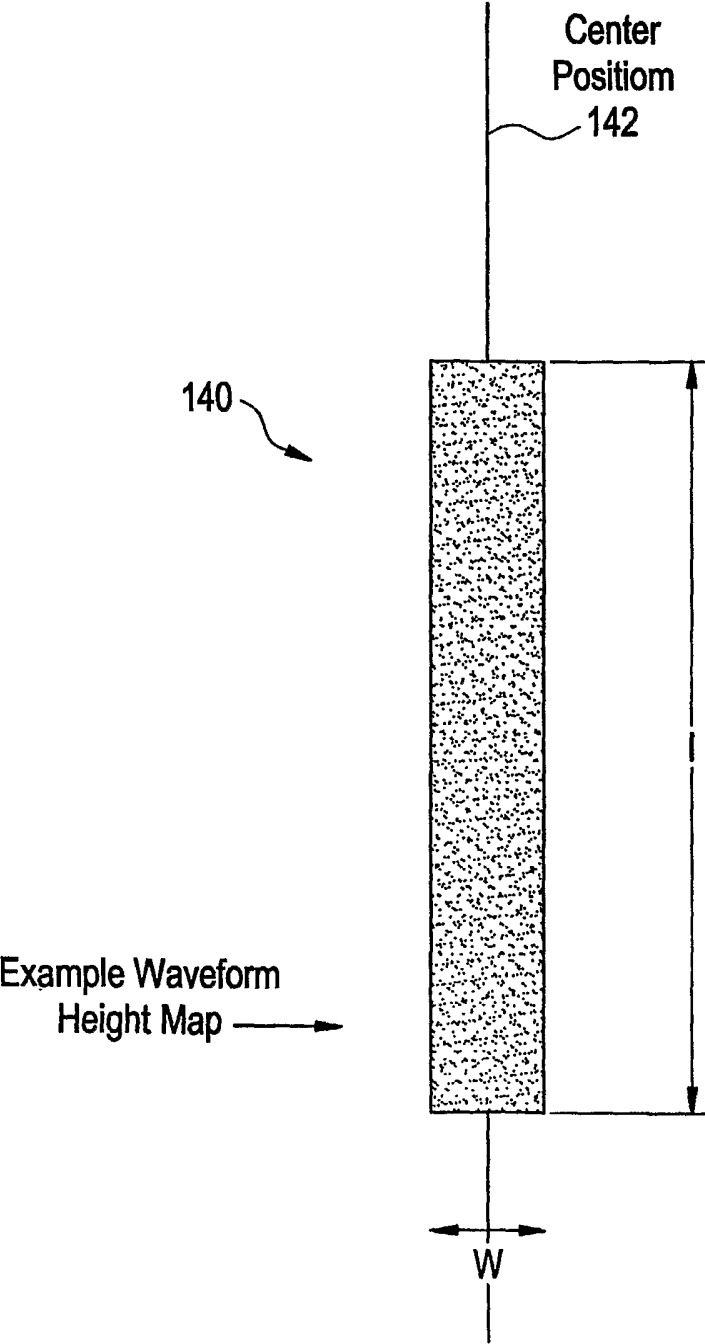


FIG. 8

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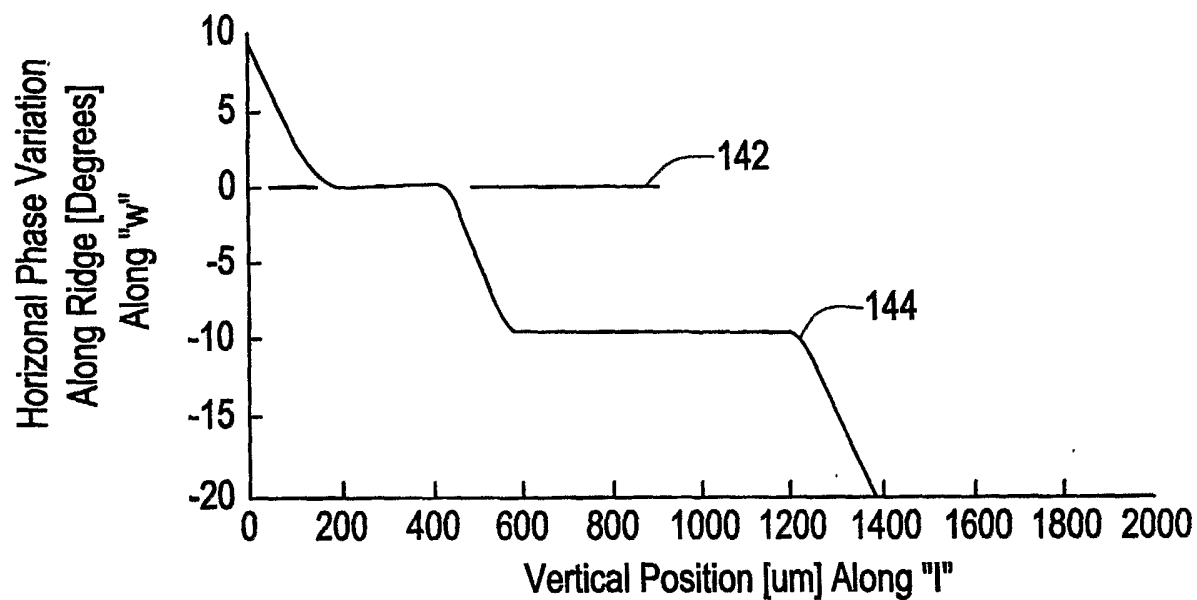


FIG. 9

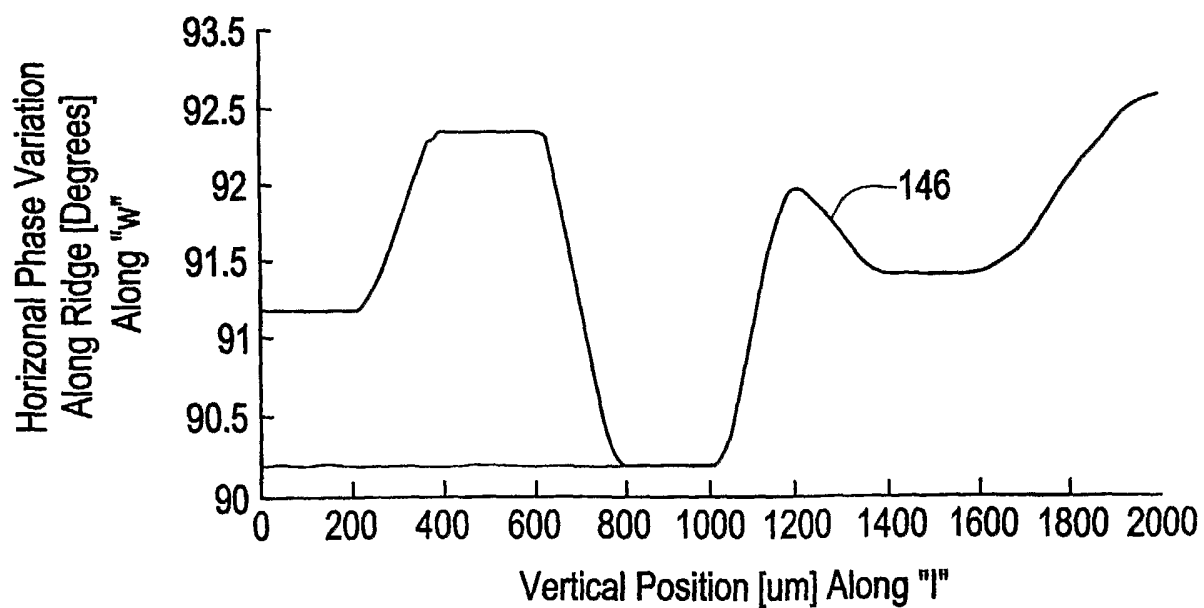


FIG. 10

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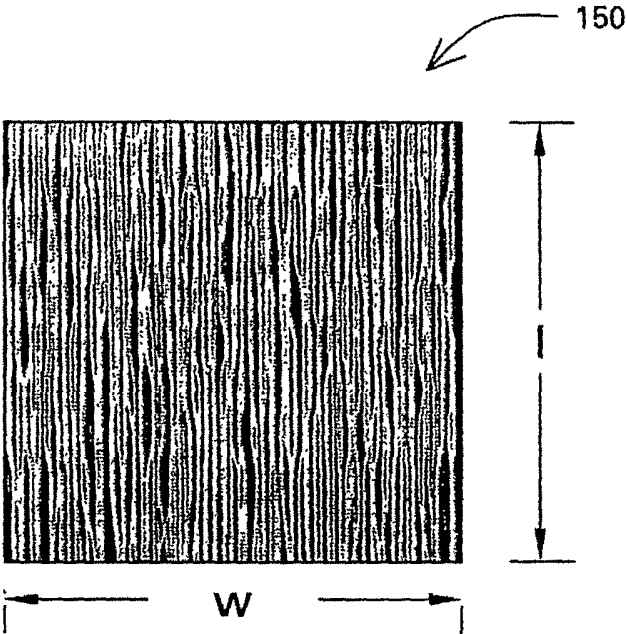


FIG. 11

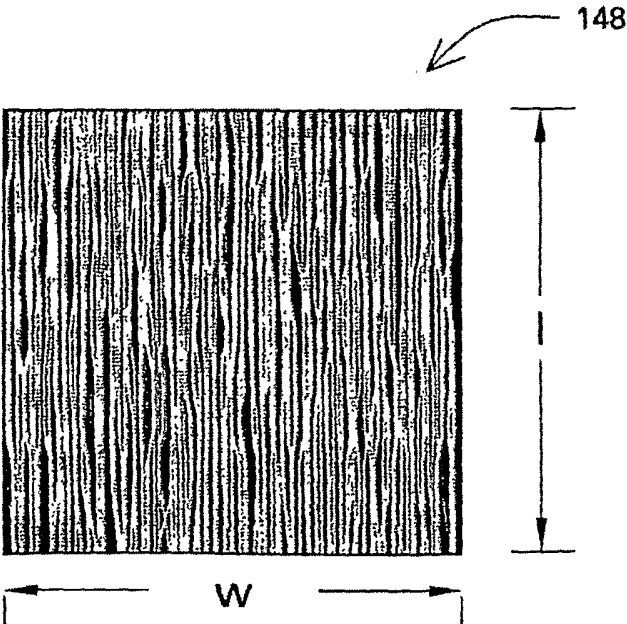


FIG. 12

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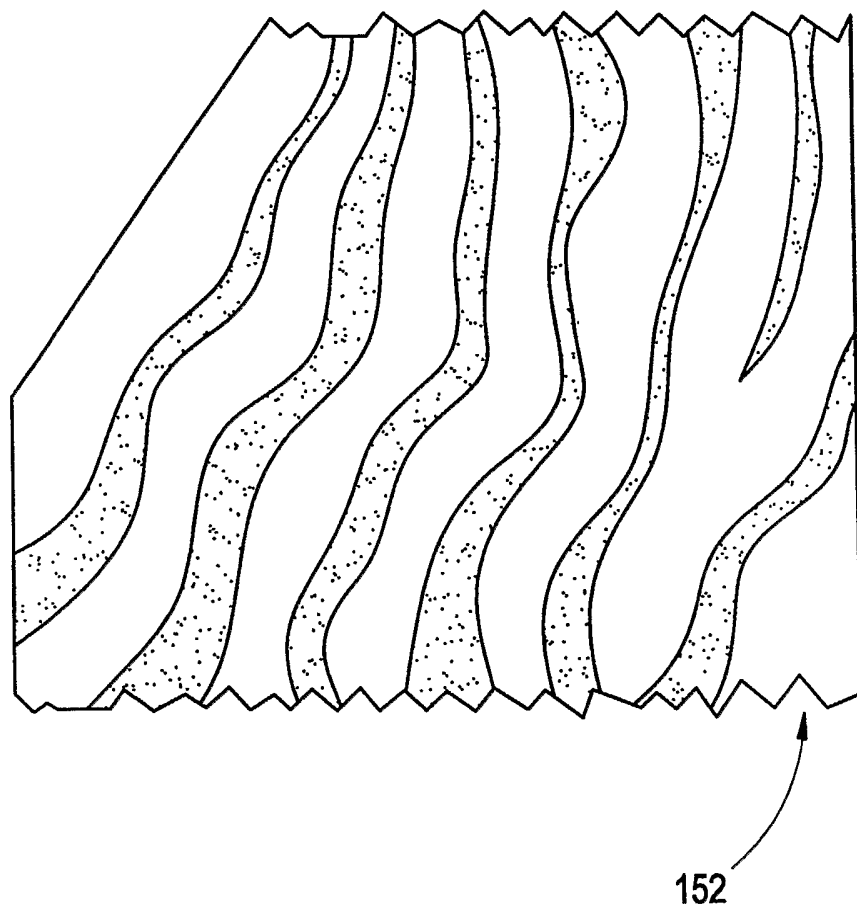


FIG. 13

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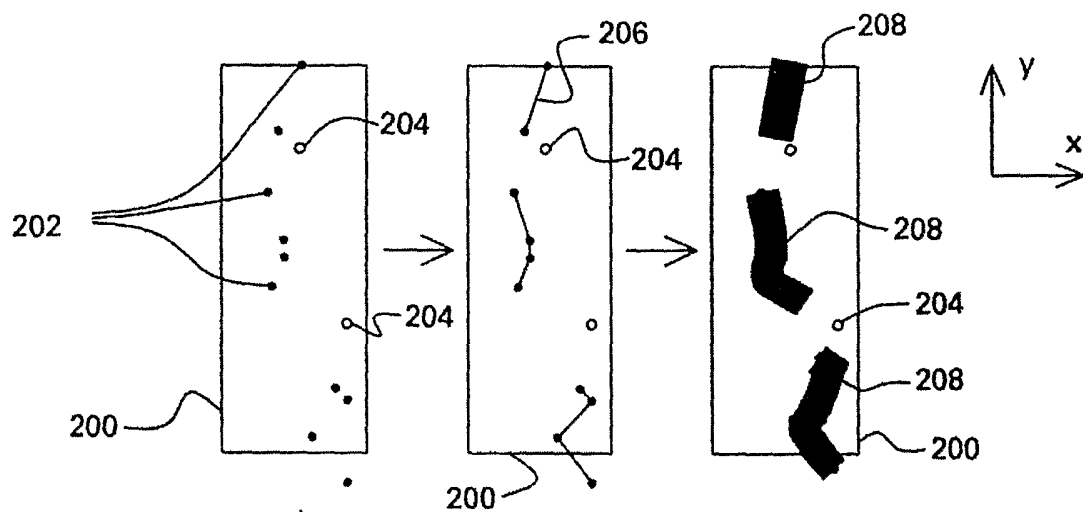


FIG. 14

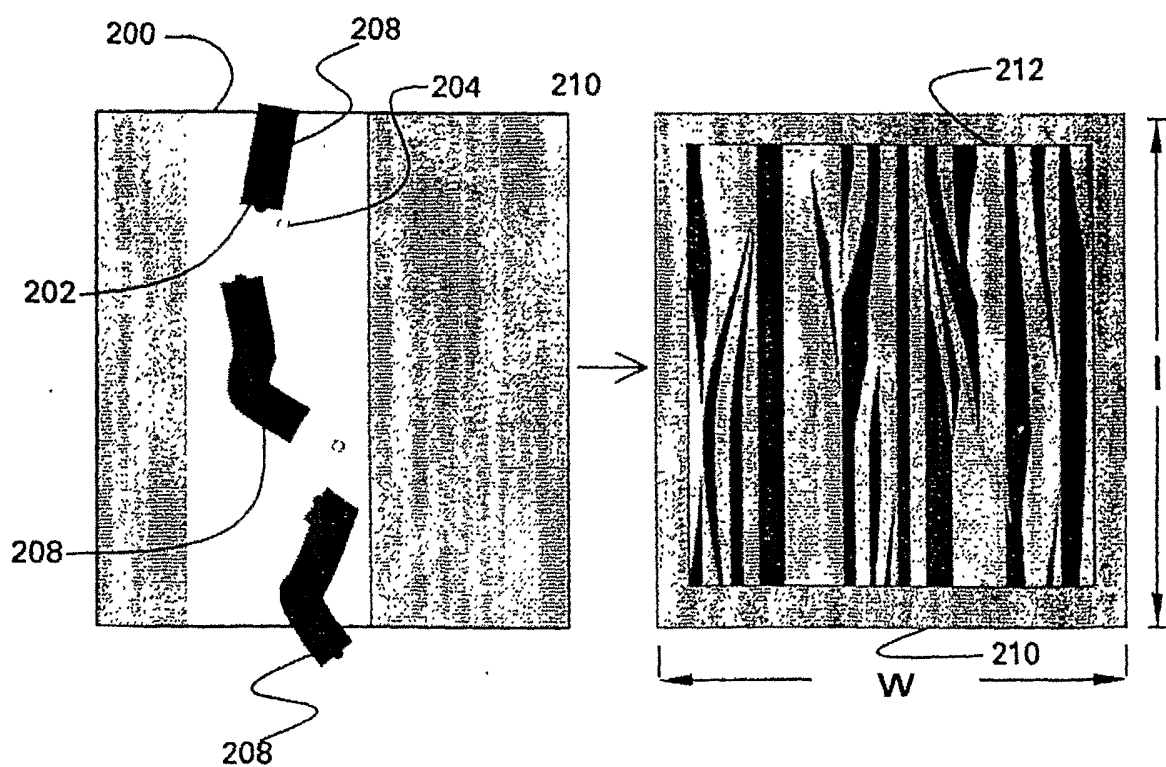


FIG. 15

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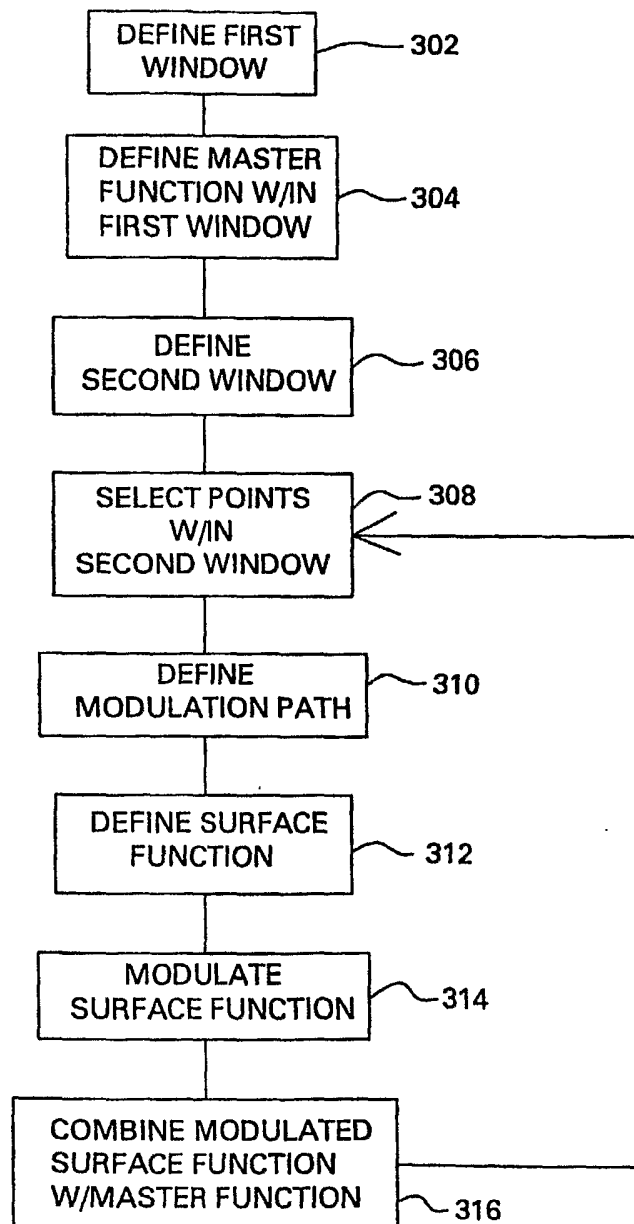


FIG.16

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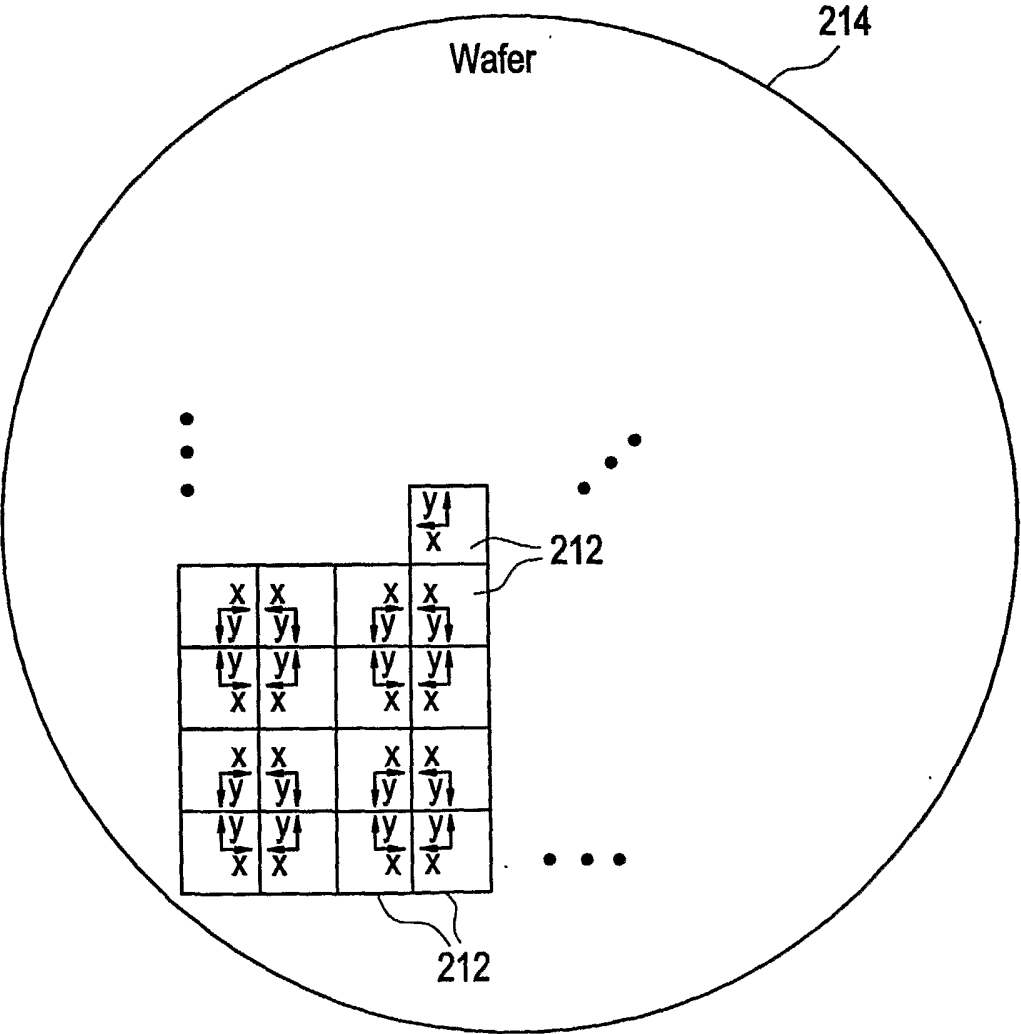


FIG. 17

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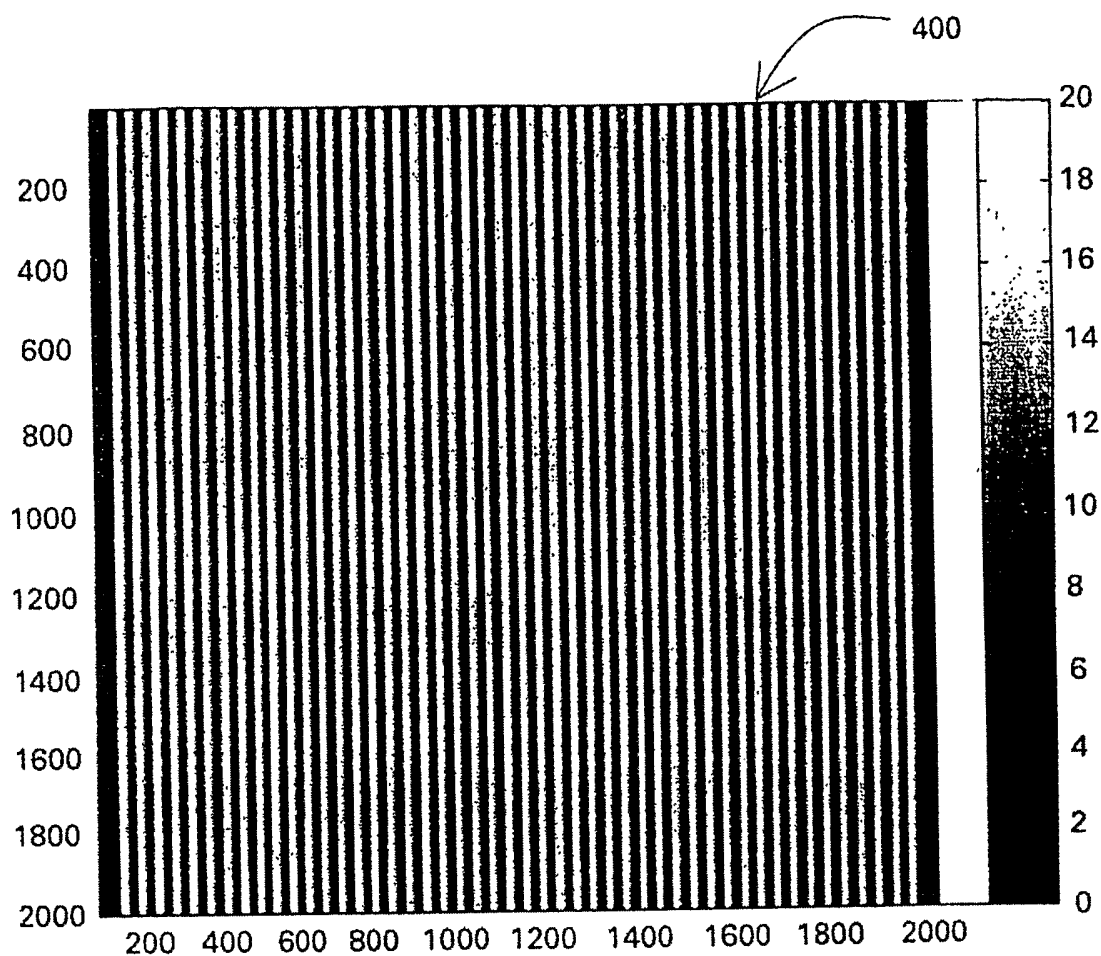


FIG. 18

Normalized auto correlation of light directing structure

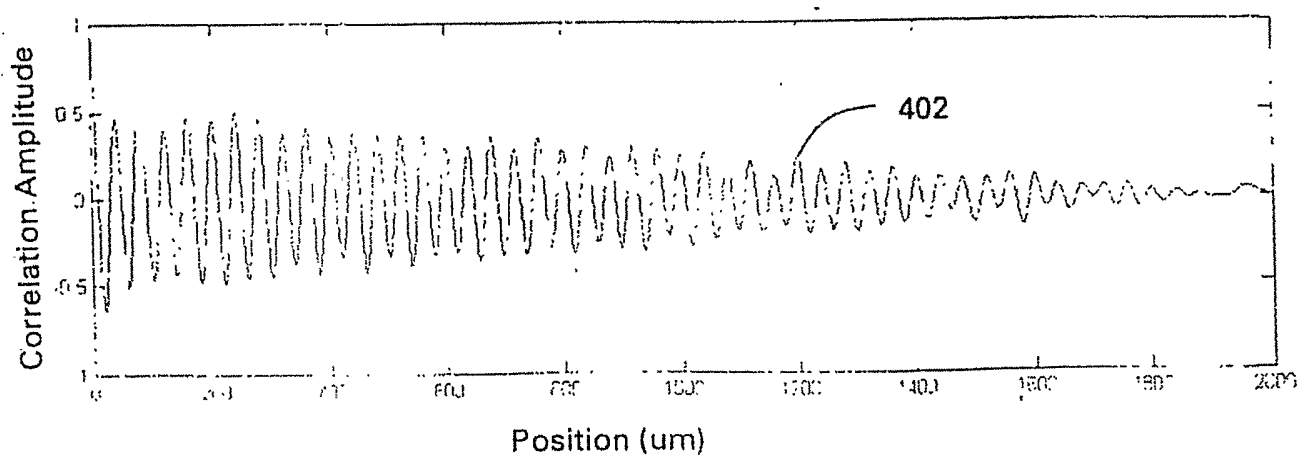


FIG. 19

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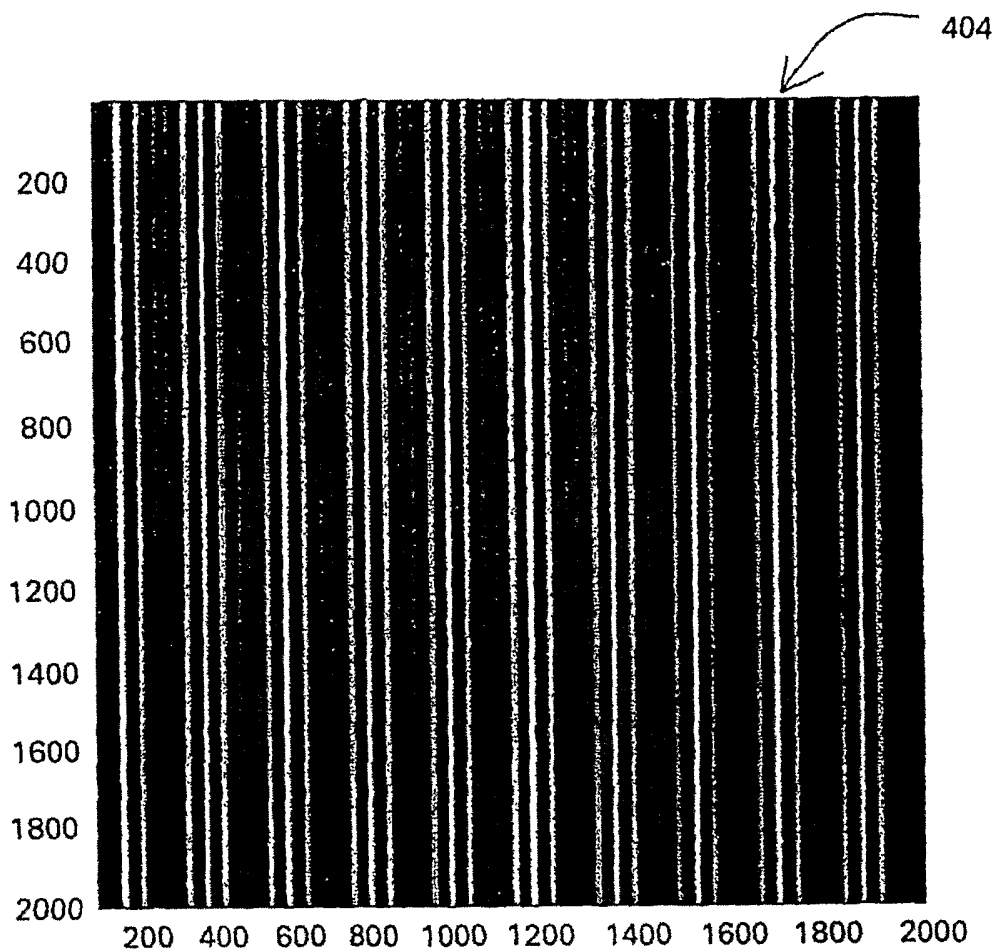


FIG. 20

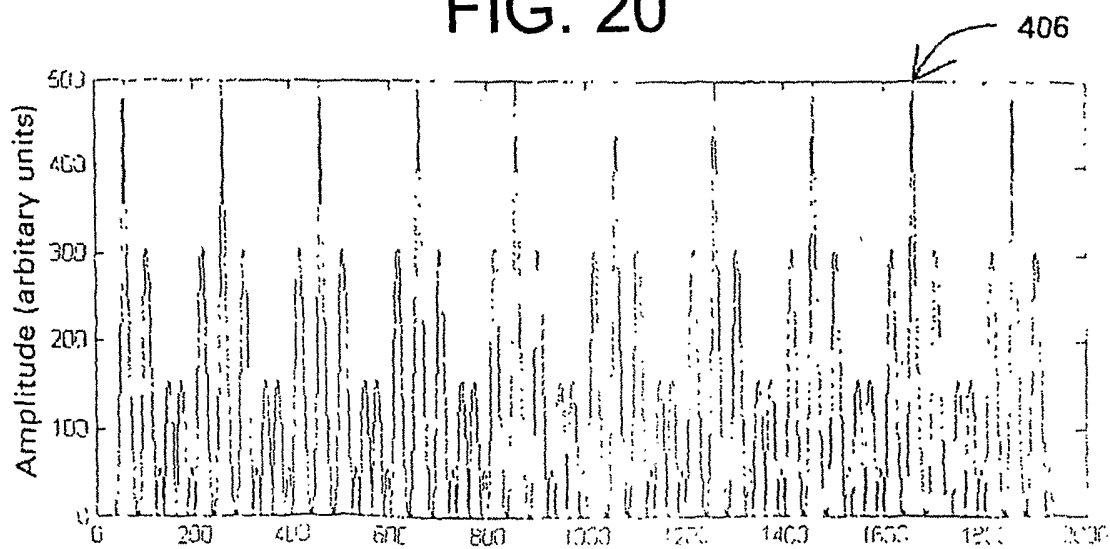
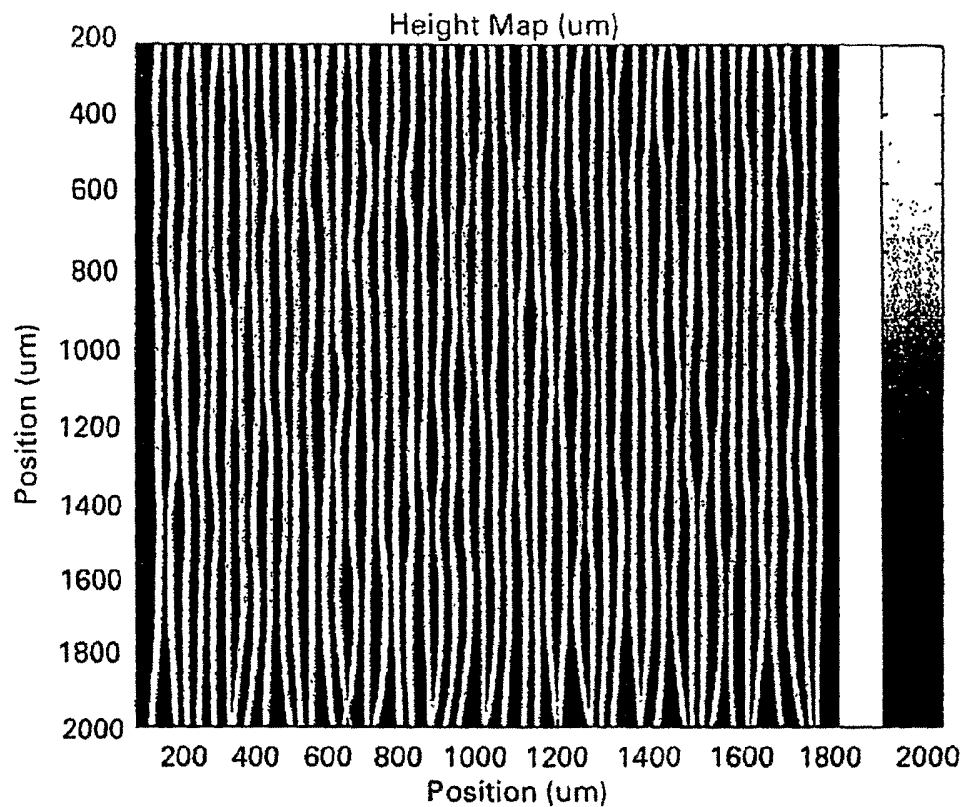


FIG. 21

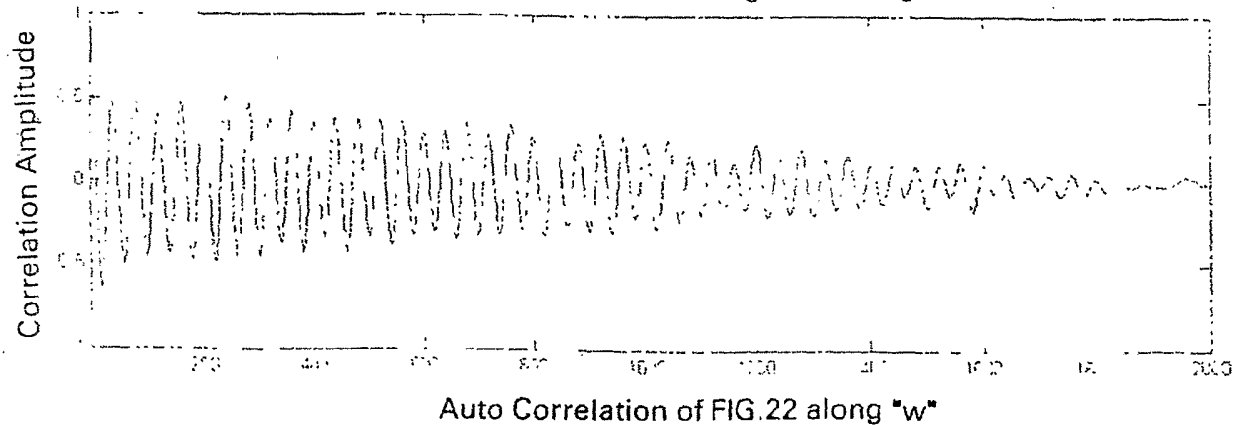
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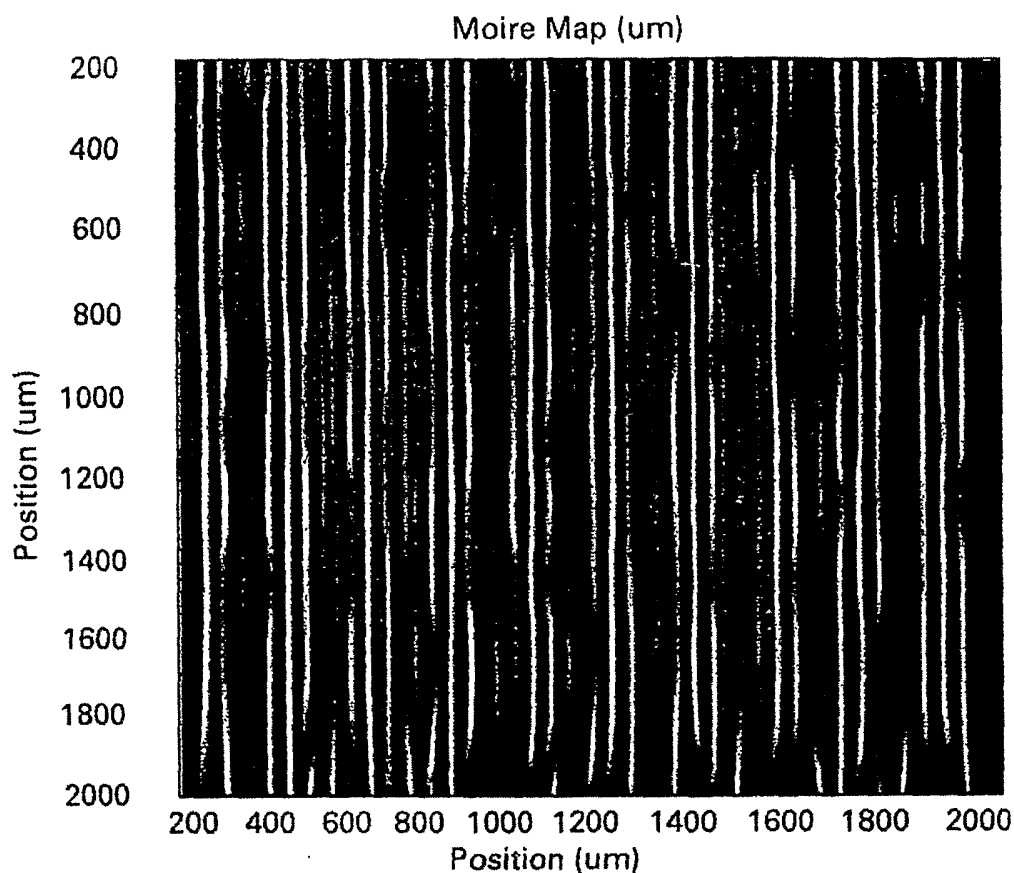
The Prism Array of FIG.18 with
Full Cycle Randomization with
Superimposed Phase modulated
"Prism Wave Forms"

FIG. 22

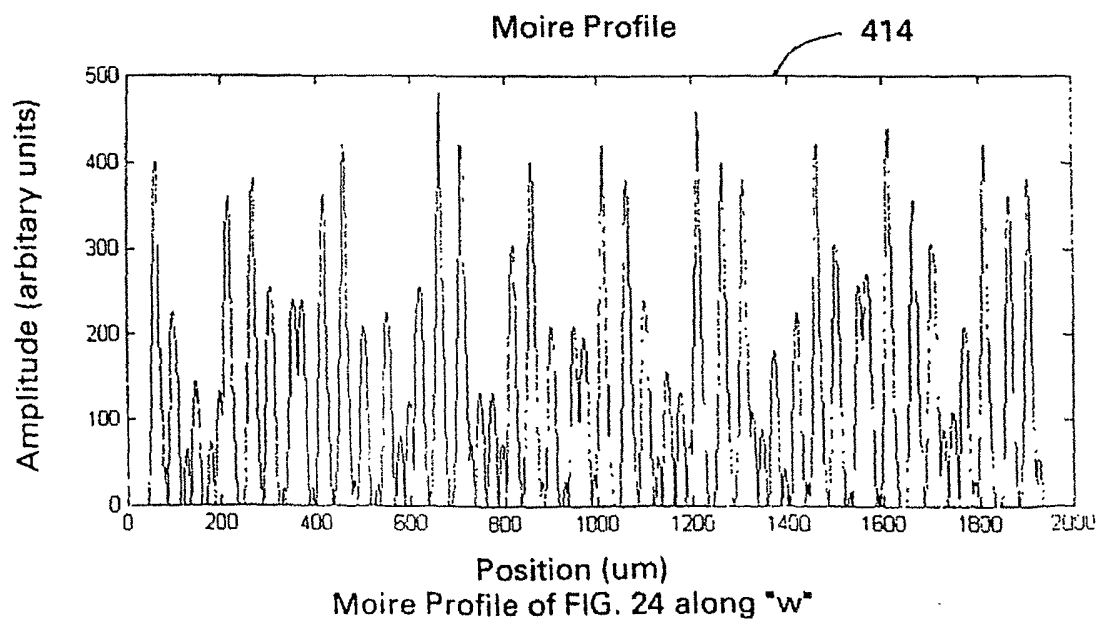
Normalized auto correlation of light directing structure

**FIG. 23**

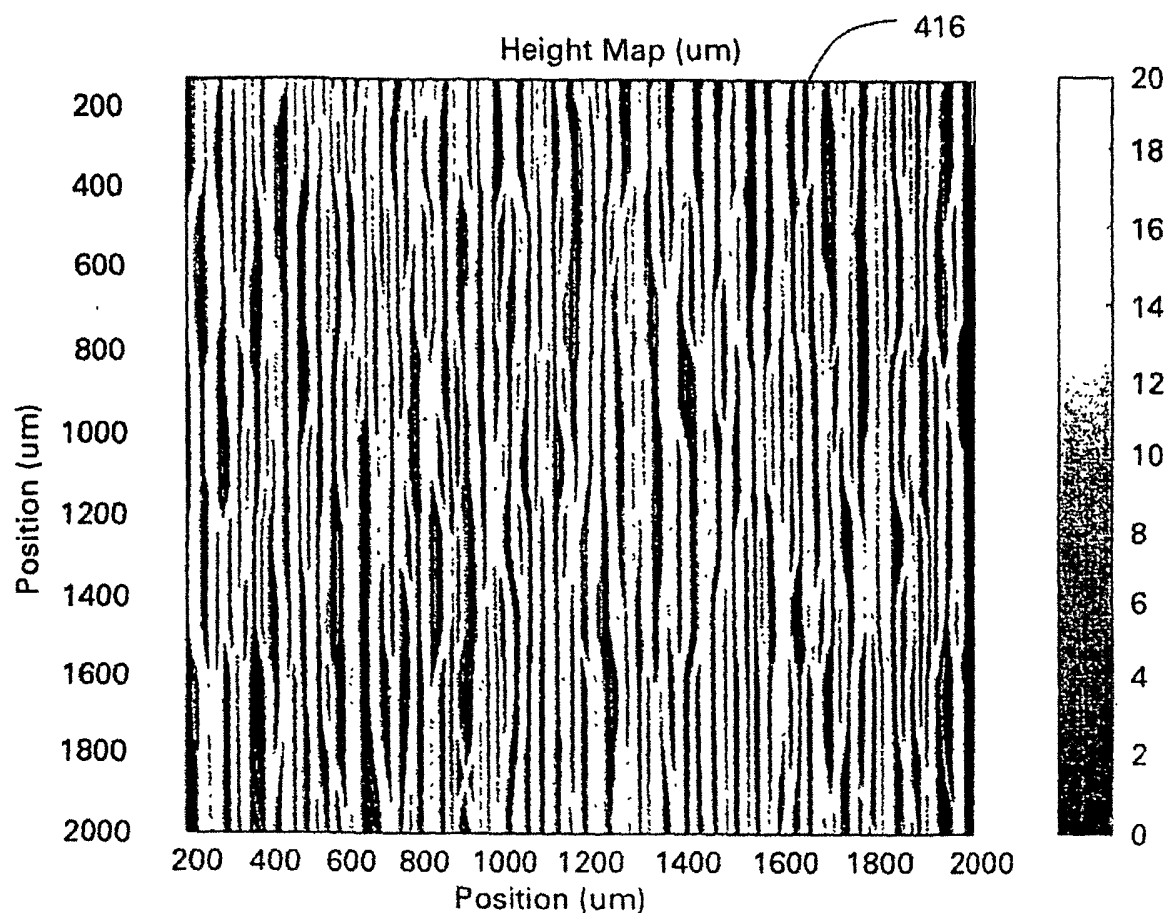
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Moire Map of The Prism Array of FIG. 22
with a 50 um Reference Prism Array

FIG. 24**FIG. 25**

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The Prism Array of FIG.18 with
Full Cycle Randomization with
Superimposed Phase modulated
"Prism Wave Forms"

FIG. 26

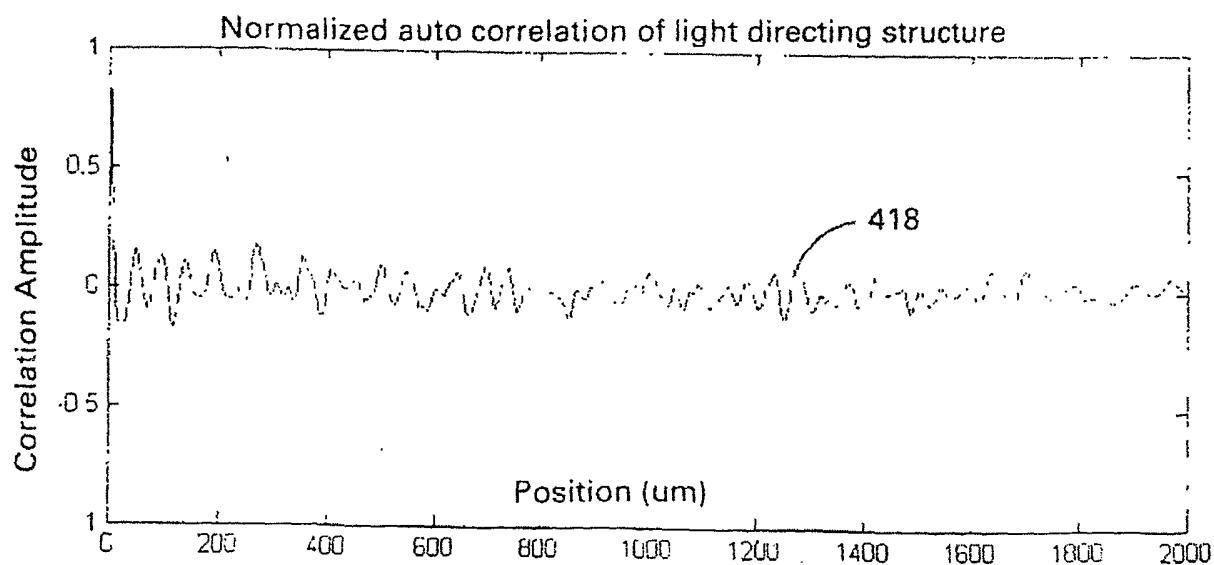
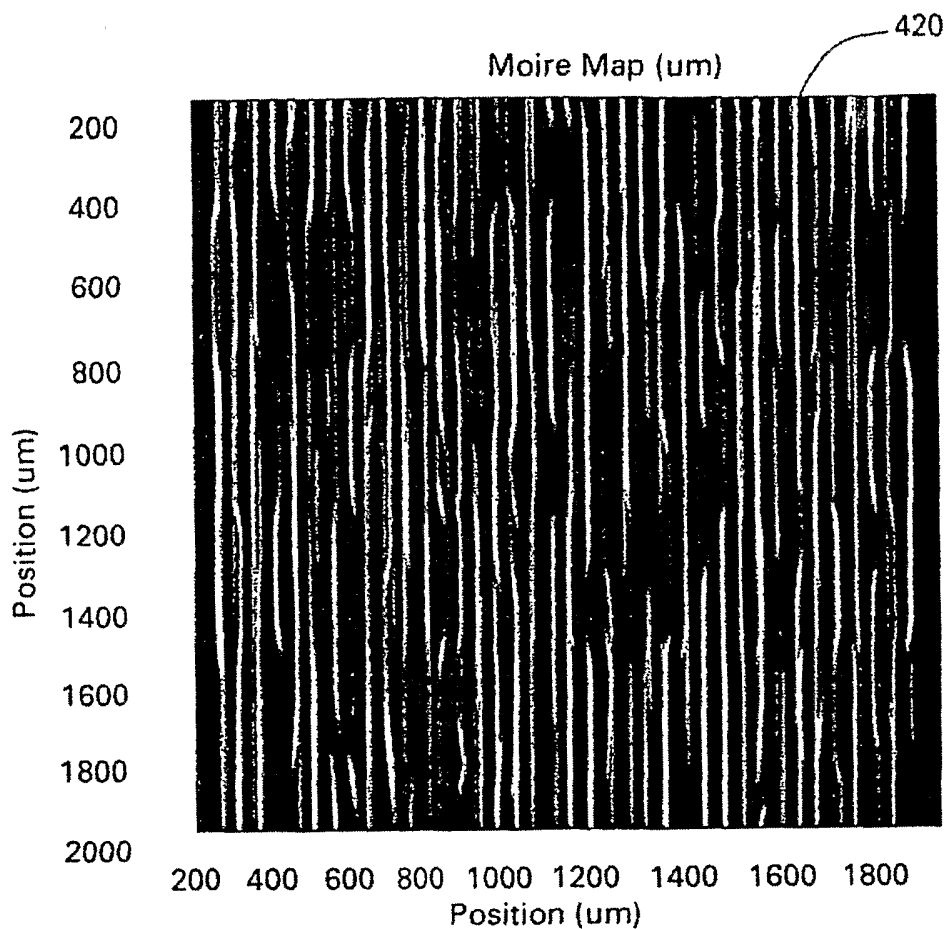


FIG. 27

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Moire Map of FIG.26

FIG. 28

Moire Profile

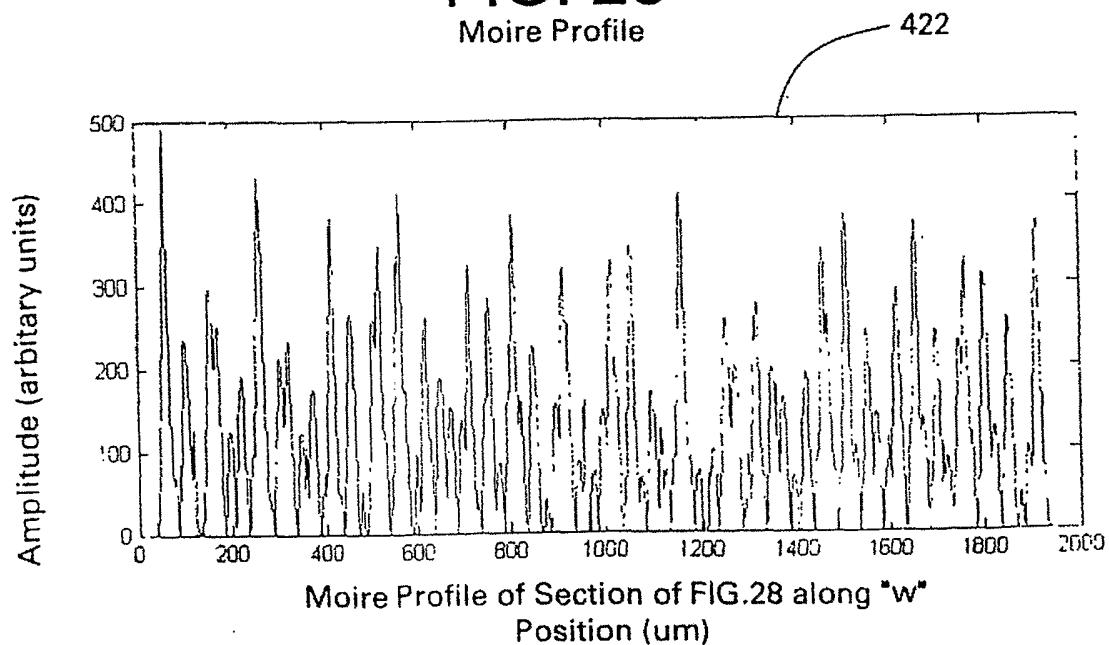
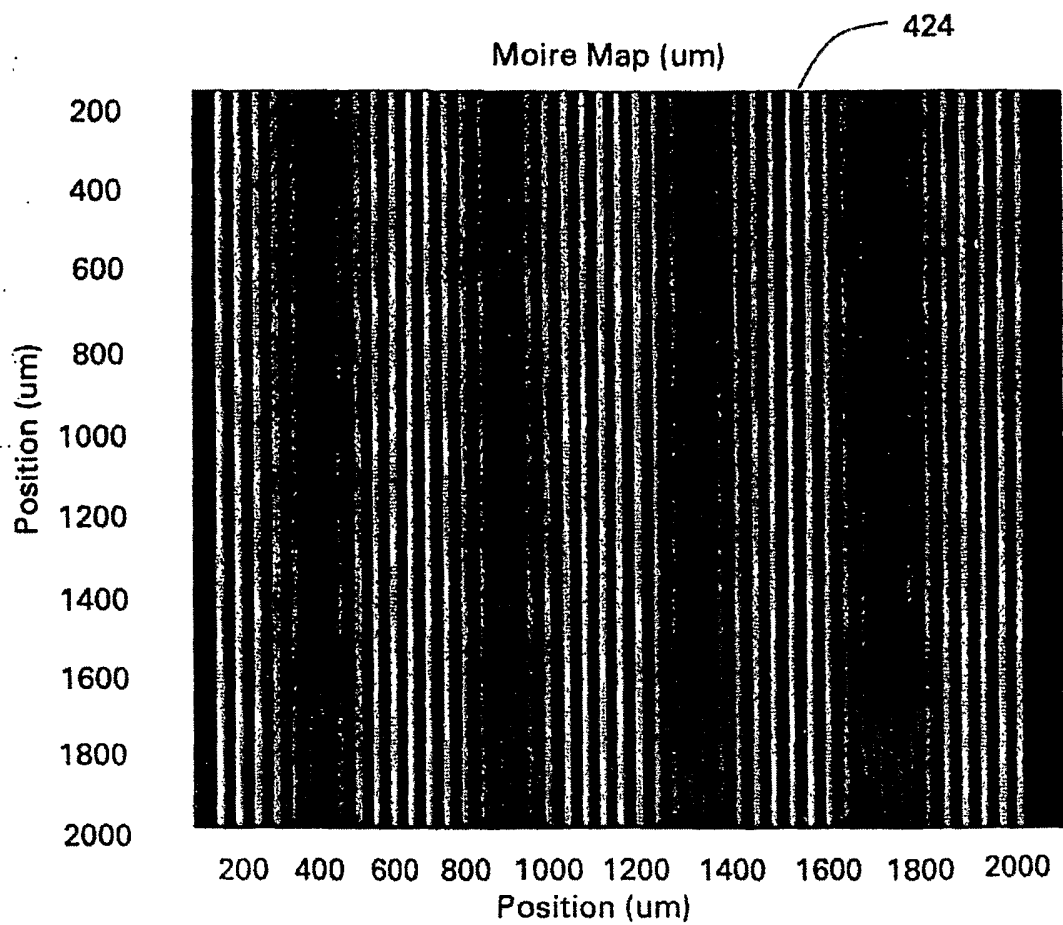


FIG. 29

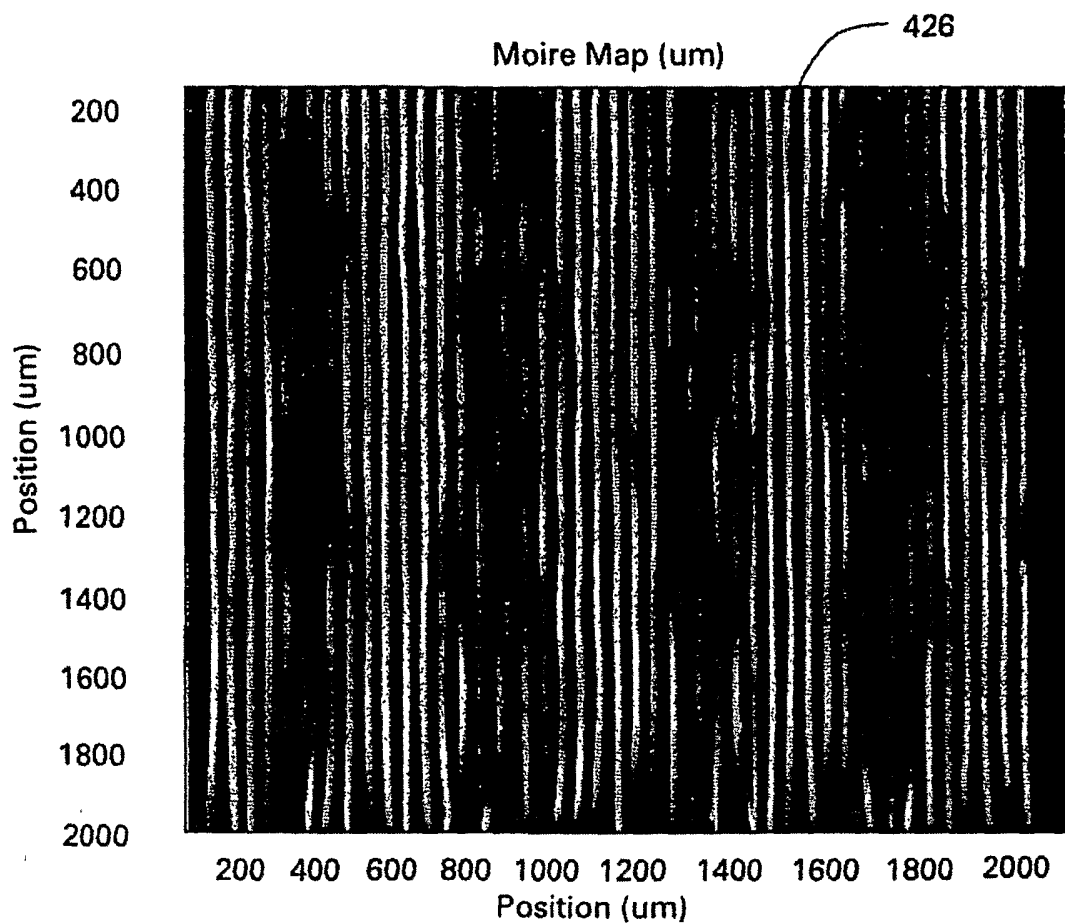
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Moire Map of the 40 um Pitch Prism Array
Against A 44 um Pitch Reference Prism Array

FIG. 30

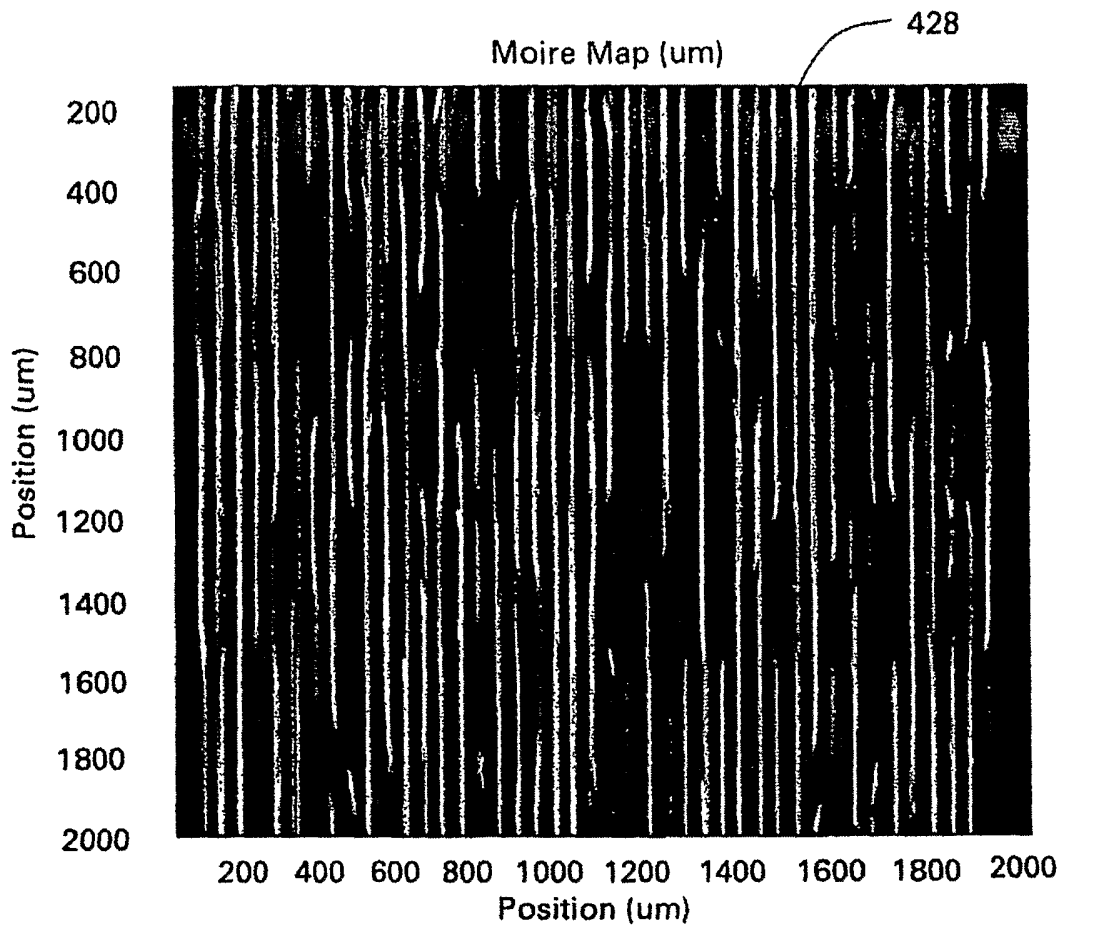
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Moire Map of the 40 um Pitch Prism Array of FIG.22
Against A 44 um Pitch Reference Prism Array

FIG. 31

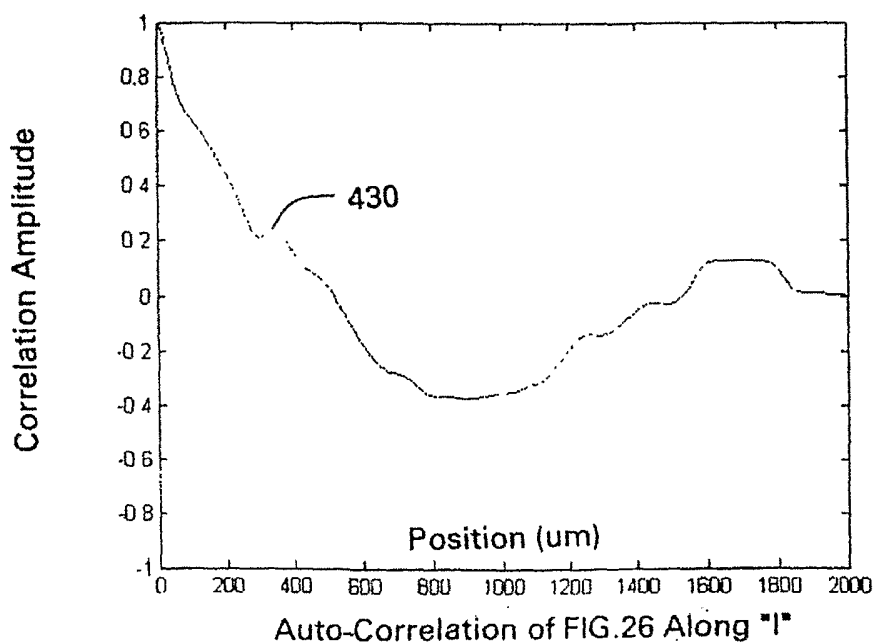
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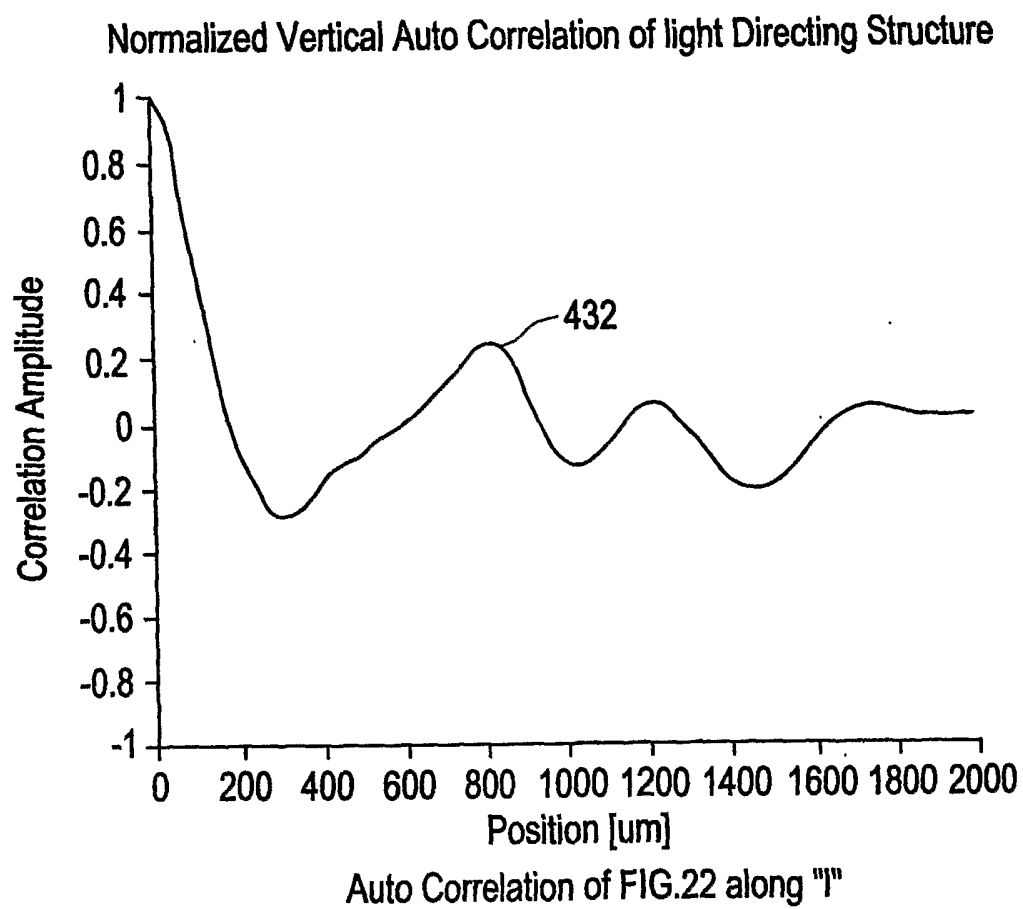
Moire Map of FIG. 26 Against a 44 um Pitch Reference Prism Array

FIG. 32

Normalized auto correlation of light directing structure

**FIG. 33**

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**FIG. 34**

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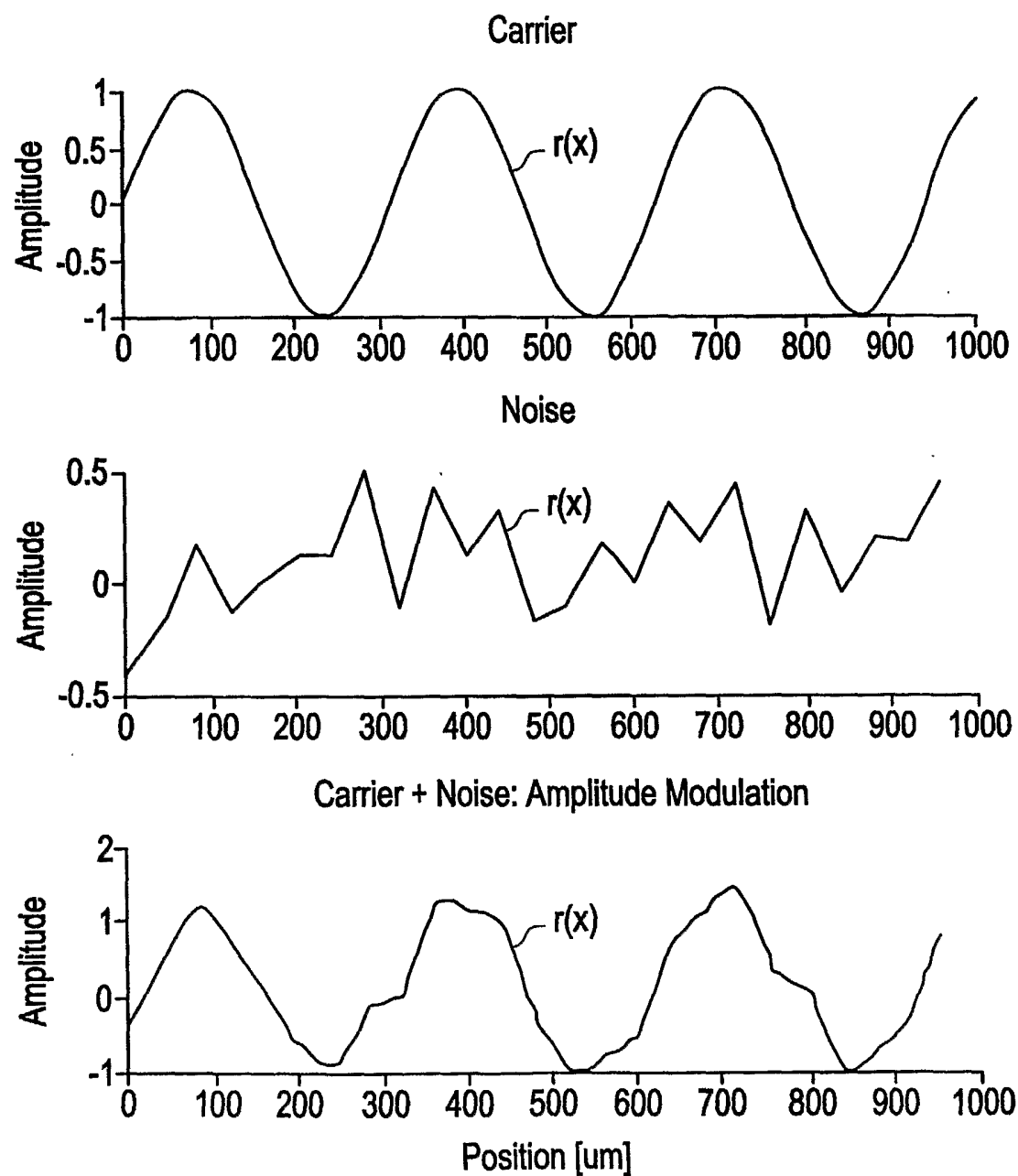
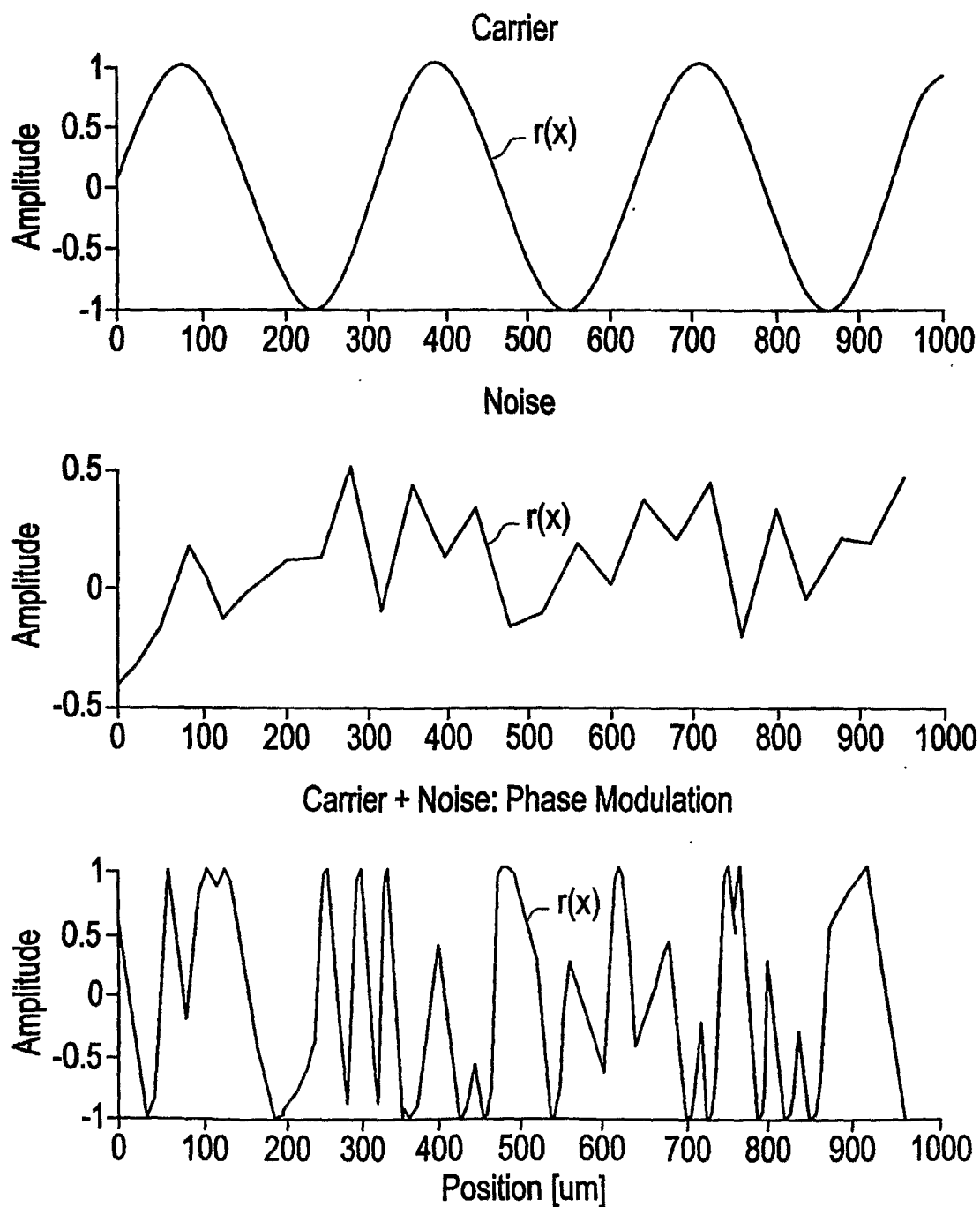
Amplitude modulation example $r(x) + \sin(x/50)$

FIG. 35

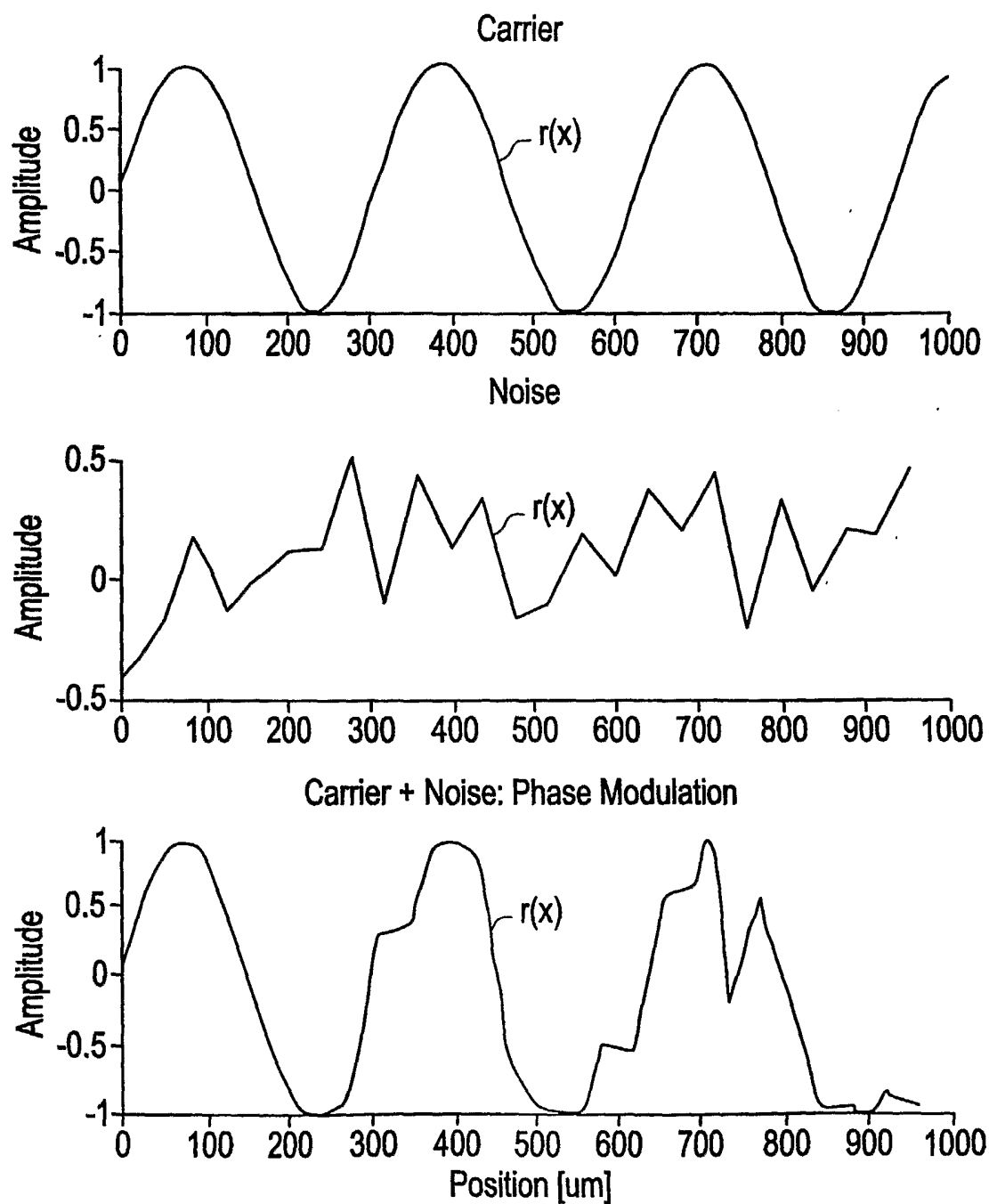
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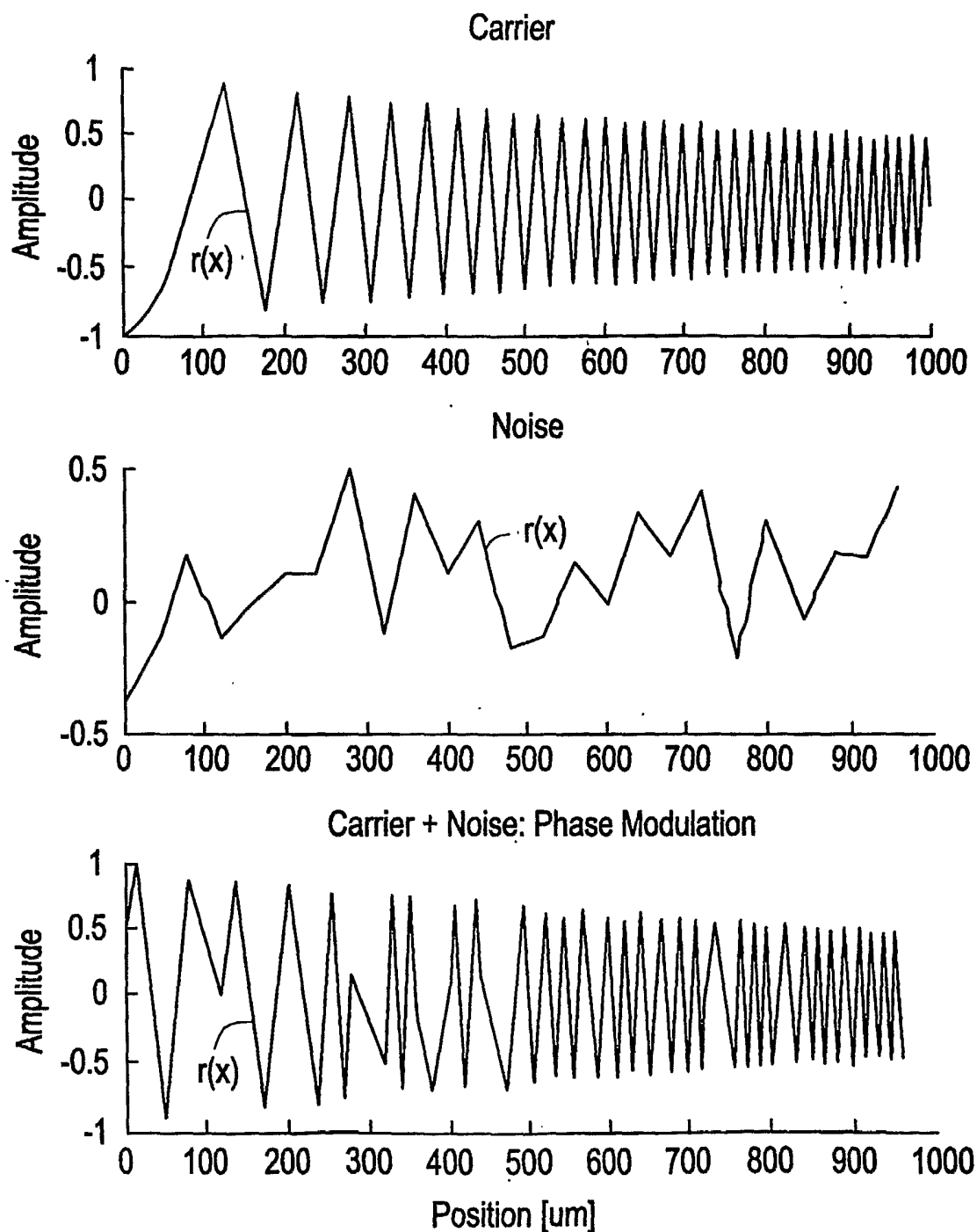
Phase modulation example $\sin(x/50+10r(x))$

FIG. 36

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Frequency modulation example $\sin(x/50 + 10r(x))$ **FIG. 37**

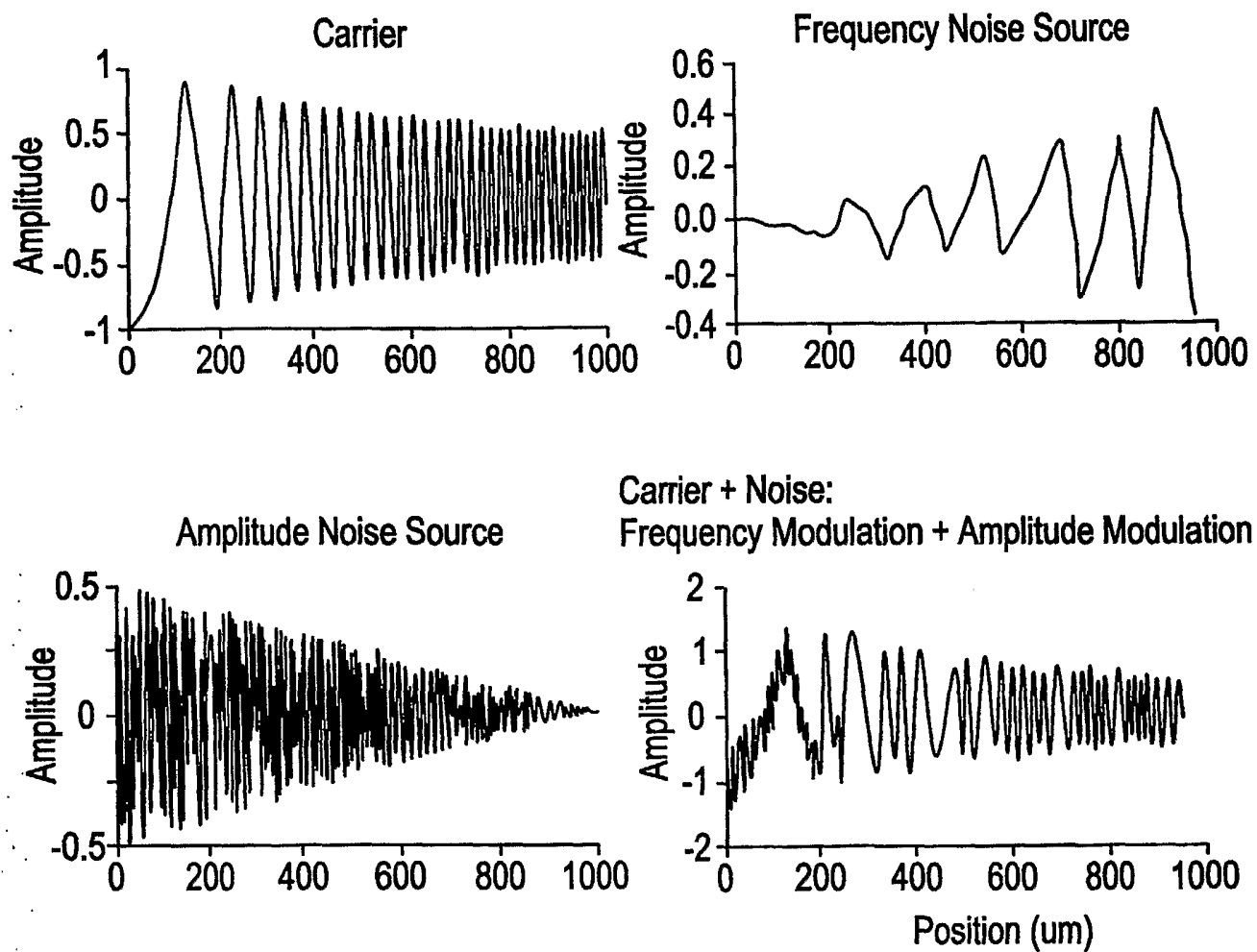
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Frequency modulation example with spatially varying carrier:
 $\text{sawtooth}(x (5000+10r(x))) * (1000)/(x+1000)$

FIG.38

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Frequency and Amplitude modulation example
 with spatially varying carrier and noise functions:
 $\text{sawtooth}(x(5000+10r(x)))*(1000)/(x+1000)$

FIG. 39

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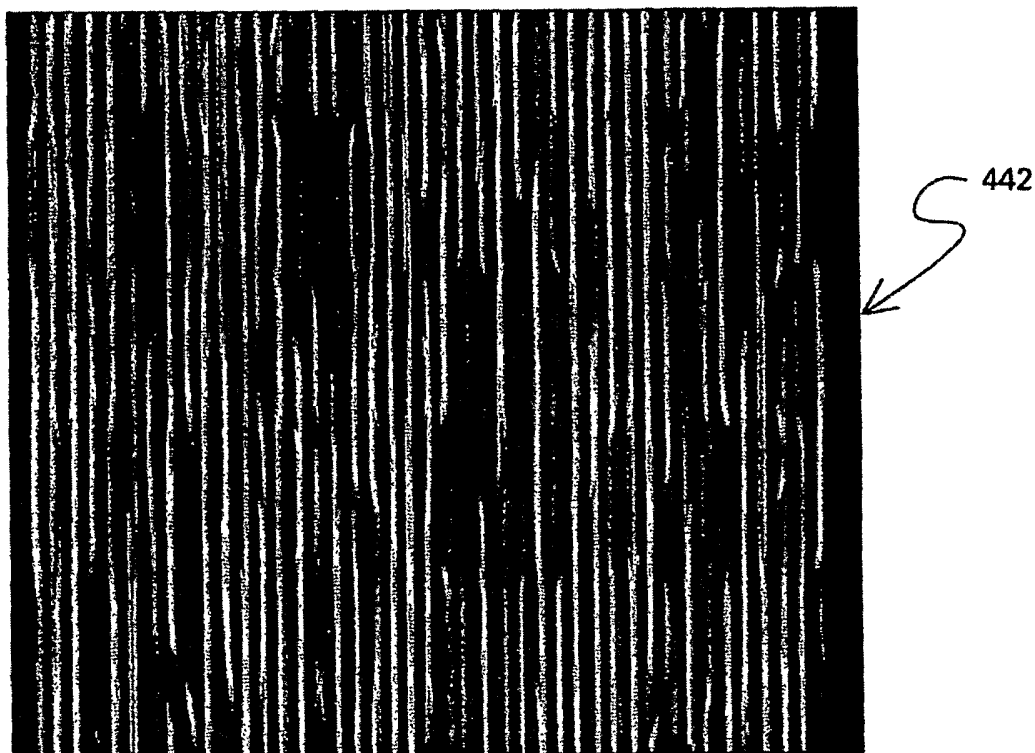


FIG. 40

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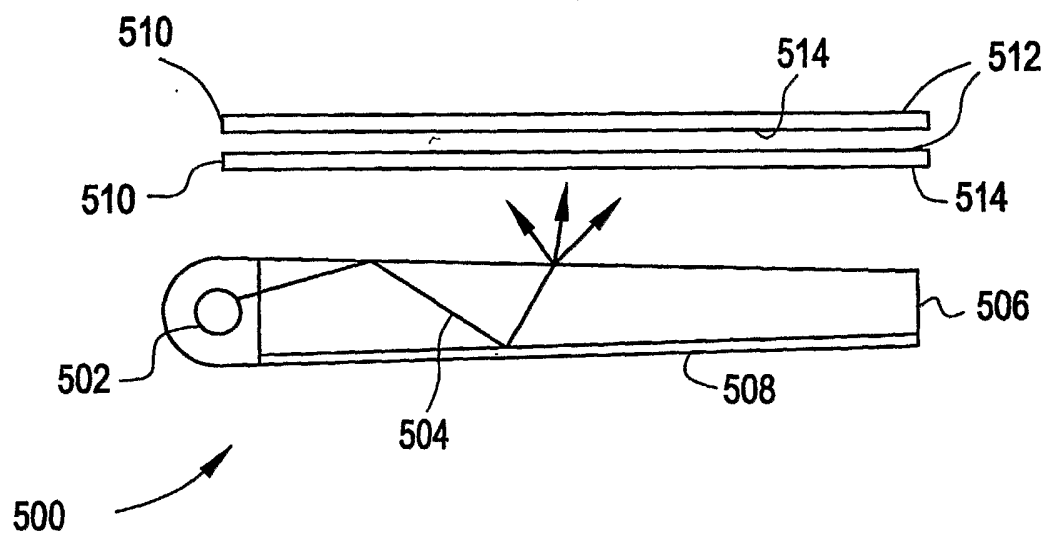


FIG. 41

PATENT COOPERATION TREATY

PCT

DECLARATION OF NON-ESTABLISHMENT OF INTERNATIONAL SEARCH REPORT

(PCT Article 17(2)(a), Rules 13ter.1(c) and Rule 39)

Applicant's or agent's file reference RD29554	IMPORTANT DECLARATION	Date of mailing(day/month/year) 10/10/2003
International application No. PCT/US 03/ 15035	International filing date(day/month/year) 13/05/2003	(Earliest) Priority date(day/month/year) 20/05/2002
International Patent Classification (IPC) or both national classification and IPC G02B5/02		
Applicant GENERAL ELECTRIC COMPANY		

This International Searching Authority hereby declares, according to Article 17(2)(a), that **no international search report will be established** on the international application for the reasons indicated below

1. ☐ The subject matter of the international application relates to:
 - a. ☐ scientific theories.
 - b. ☐ mathematical theories
 - c. ☐ plant varieties.
 - d. ☐ animal varieties.
 - e. ☐ essentially biological processes for the production of plants and animals, other than microbiological processes and the products of such processes.
 - f. ☐ schemes, rules or methods of doing business.
 - g. ☐ schemes, rules or methods of performing purely mental acts.
 - h. ☐ schemes, rules or methods of playing games.
 - i. ☐ methods for treatment of the human body by surgery or therapy.
 - j. ☐ methods for treatment of the animal body by surgery or therapy.
 - k. ☐ diagnostic methods practised on the human or animal body.
 - l. ☐ mere presentations of information.
 - m. ☐ computer programs for which this International Searching Authority is not equipped to search prior art.
2. ☒ The failure of the following parts of the international application to comply with prescribed requirements prevents a meaningful search from being carried out:

☐ the description
☒ the claims
☐ the drawings
3. ☐ The failure of the nucleotide and/or amino acid sequence listing to comply with the standard provided for in Annex C of the Administrative Instructions prevents a meaningful search from being carried out:

☐ the written form has not been furnished or does not comply with the standard.

☐ the computer readable form has not been furnished or does not comply with the standard.
4. Further comments:

see further information PCT/ISA 203

Name and mailing address of the International Searching Authority



European Patent Office, P.B. 5818 Patentlaan 2
NL-2280 HV Rijswijk
Tel. (+31-70) 340-2040, Tx. 31 651 epo nl,
Fax: (+31-70) 340-3016

Authorized officer

Cornelia Schulze

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 203

No search can be carried out for the present application, the reasons being as follows:

Claims 1-9,45:

Claims 1 and 45 relate to a mathematical method considered by this Authority to be covered by the provisions of Rule 39.1(i) PCT.

Consequently, no search will be carried out.

Similar considerations apply for claims 2-9, dependent on claim 1.

Claims 10-15,43,44:

The subject-matter of claim 10 is an optical substrate produced by the method of claim 1. Device claims trying to define a product solely by defining the method how the product is obtained is only allowed in exceptional cases usually related to chemical compounds.

Similar considerations apply for claims 11-15, 43,44, dependent on claim 10.

Claims 16-24:

The technical terms "correlation function" and "correlation length" employed in claim 16 do not have a well defined, generally accepted meaning in the art, contrary to the requirements of Rule 10.1(e) PCT. Moreover, claim 16 does not meet the requirements of Article 6 PCT in that the matter for which protection is sought is not clearly defined. The following functional statements do not enable the skilled person to determine which technical features are necessary to perform the stated function "producing specular and diffuse light".

Similar considerations apply for claims 17-24, dependent on claim 16.

Claims 25-28:

Regarding the technical term "correlation length" employed in claim 25 see paragraph above.

Moreover, claim 25 does not meet the requirements of Article 6 PCT in that the matter for which protection is sought is not clearly defined. The claim attempts to define the subject-matter in terms of the result to be achieved which merely amounts to a statement of the underlying problem.

Similar considerations apply for claims 26-28, dependent on claim 25.

Claims 29-39,40-42:

The term "surface structure functions" used in claims 29 and 40 is vague and unclear and leaves the reader in doubt as to the meaning of the technical feature to which it refers, thereby rendering the definition of the subject-matter of said claims unclear (Article 6 PCT).

Similar considerations apply for claims 30-39, dependent on claim 29 and for claims 41-42, dependent on claim 40.

In view of the large number and also the wording of the independent claims 1,10,16,25,29,40,45-50,56,57,61,75 presently on file, which render it difficult, if not impossible, to determine the matter for which protection is sought, and the features that are essential to a possible invention. The present application fails to comply with the conciseness requirements of Article 6 PCT (see also Rule 6.1(a) PCT) to such an extent that a meaningful search is impossible.

Consequently, no search report can be established for the present

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 203

application.

The applicant's attention is drawn to the fact that claims relating to inventions in respect of which no international search report has been established need not be the subject of an international preliminary examination (Rule 66.1(e) PCT). The applicant is advised that the EPO policy when acting as an International Preliminary Examining Authority is normally not to carry out a preliminary examination on matter which has not been searched. This is the case irrespective of whether or not the claims are amended following receipt of the search report or during any Chapter II procedure. If the application proceeds into the regional phase before the EPO, the applicant is reminded that a search may be carried out during examination before the EPO (see EPO Guideline C-VI, 8.5), should the problems which led to the Article 17(2) declaration be overcome.